

Angle-resolved photoemission spectroscopy on emergent quantum materials

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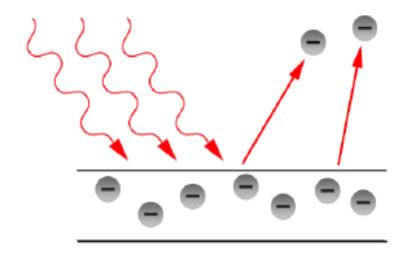


Outline

- Introduction to angle-resolved photoemission spectroscopy (ARPES)
 - The principle of ARPES
 - Current status of ARPES beamline at NSRRC
- The electronic structure of emergent materials
 - Surface states and quantum well states
 - Graphene based materials
 - Beyond graphene : 2D materials
 - Topological insulators (TIs)
 - Toward future electronic devices



What is photoemission?



Photon in -> electron out (emission)



What is photoemission spectroscopy? (photoelectron spectroscopy) (PES)

hv Monochromatized photons



Initial state: ground (neutral) state

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Conservation of energy

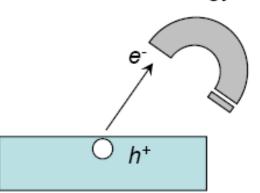
 $E_k = hv + E_i - E_f$ (most general expression)

 $\boldsymbol{E}_{\boldsymbol{k}}$: photoelectron kinetic energy

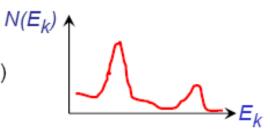
 $\boldsymbol{E_i}(N)$: total initial state system energy

 $E_f(N-1)$: total final state system energy

Electron energy analyzer

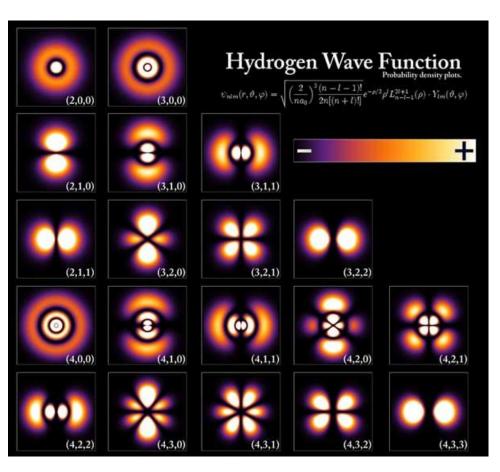


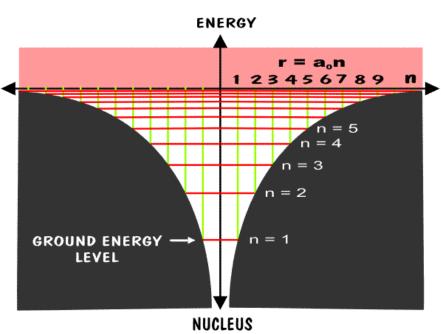
Final state: hole (excited) state



Energy Distribution Curve (EDC) (Spectrum)

The energy level of hydrogen atom

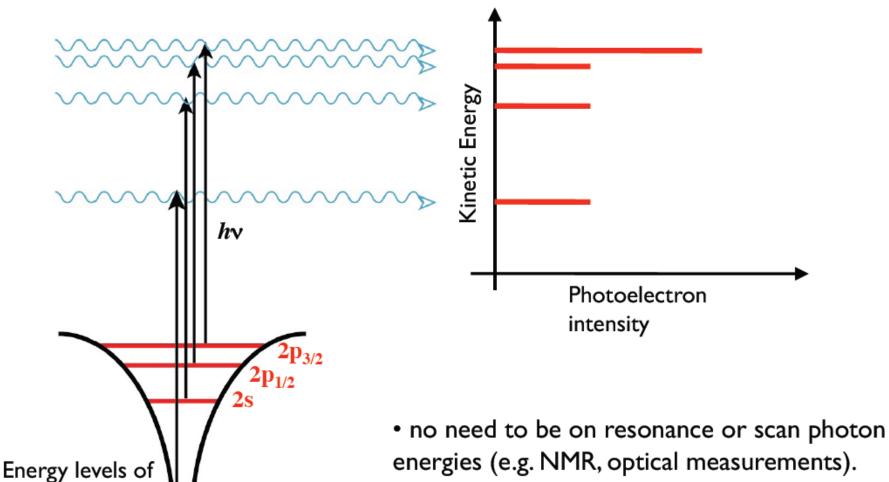






Electron ionization levels are formed from discrete levels in an atom

Energy conservation: $hv - E_I = KE$



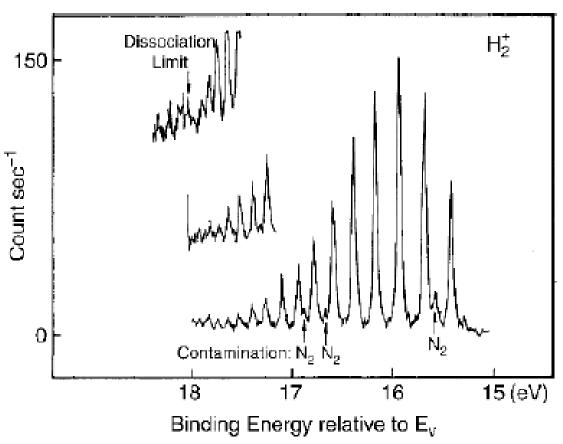


ionized Ne+

1s

Just need photons to have high enough energy!

Xeon gas phase test



Sect

nt: R4000-4MS278
: Scienta 1/27/2011
rgy: 2 eV
 Scienta 59000 ms
 1

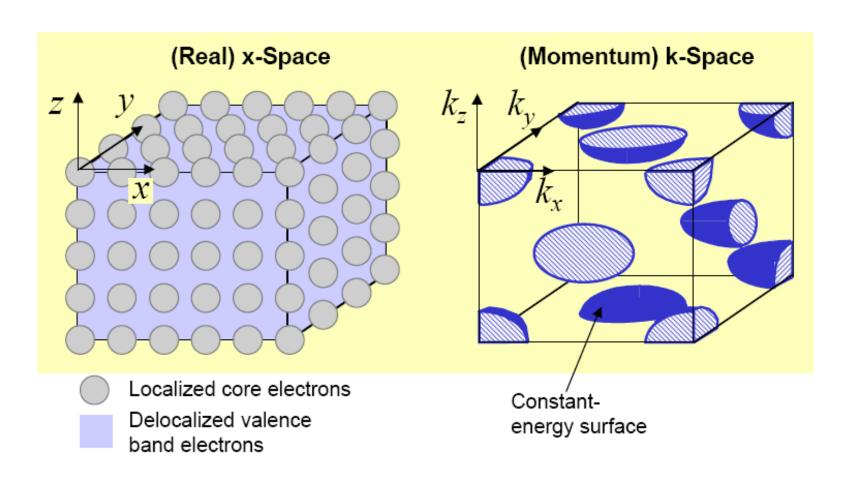
nt Resolution: 3.8 meV

nt Resolution: 1.7 meV

Killed Ellergy Telative to Ell



The crystal structure and momentum space



nickel (II) oxide

primitive vectors **a**₁, **a**₂, **a**₃
reciprocal lattice vector **b**₁,**b**₂,**b**₃

$$\vec{b}_1 = 2\pi \frac{\vec{a}_2 \times \vec{a}_3}{V}$$

$$\vec{b}_2 = 2\pi \frac{\vec{a}_3 \times \vec{a}_1}{V}$$

$$\vec{b}_3 = 2\pi \frac{\vec{a}_1 \times \vec{a}_2}{V}$$

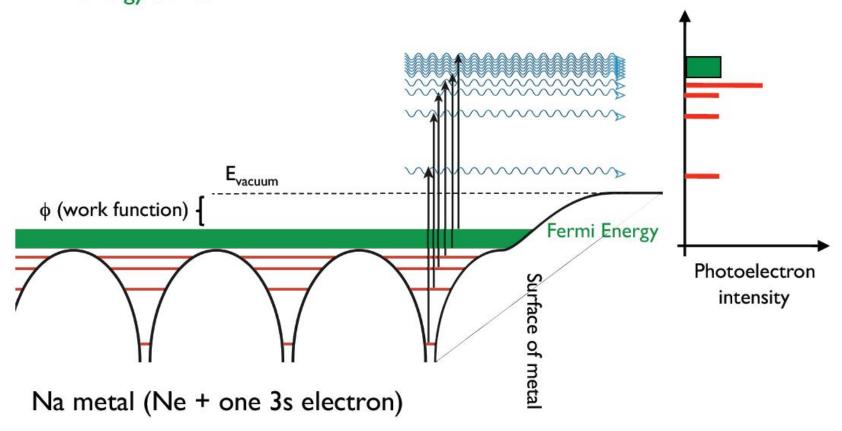
$$V = \vec{a}_1 \cdot \vec{a}_2 \times \vec{a}_3$$

reciprocal lattice G:

$$\vec{G} = l\vec{b}_1 + m\vec{b}_2 + n\vec{b}_3$$

l,m,n are any integers

- Deeply bound "core" electrons remain basically unchanged
- Outermost "valence" electrons hybridize forming continuous "energy bands"





Band theory

Two approximations

Nearly free electrons. Electrons are non-interacting in a periodic crystal potential which is relatively weak and can be treated as a perturbation. As in the free-electron-gas model, they are still subject to the Pauli exclusion principle.

Free electron gas:

The interactions between electrons and between electrons and nuclei are turned off, subject only to the Pauli exclusion principle.

Tightly-bonding approximation

Electrons are tightly bound to particular atoms, overlapping only weakly with neighbors.

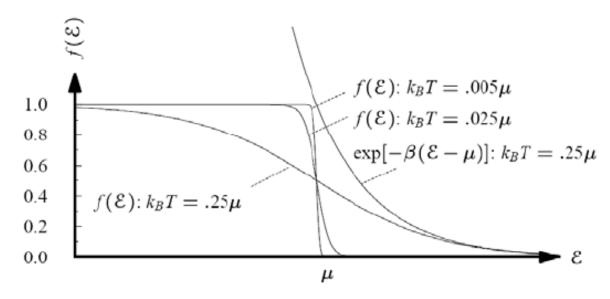
Fermi-Dirac Distribution

Almost every electronic transport property of solids is proportional to $D(\mathcal{E}_F)$.

Thermal Properties of Free Electron Gas:

Fermi function
$$f(\mathcal{E}) = \frac{1}{e^{(\mathcal{E}-\mu)/k_BT} + 1}$$

RT ~ 25 meV





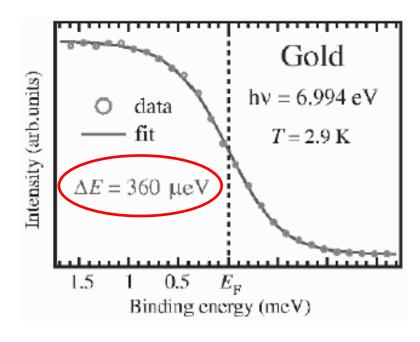


Fig. 2.3. Ultra-high resolution photoemission spectrum on a polycrystalline gold sample (evaporated Au film) for the determination of the energy resolution. The Fermi edge was measured at $T=2.9\,\mathrm{K}$ using a frequency tripled (KBe₂BO₃F₂ crystal, KBBF) YVO₃ laser for the photoexcitation ($h\nu=6.994\,\mathrm{eV}$) [15]



Why ARPES - key technique for the electronic structure mapping

- Angle-resolved photoemission spectroscopy (ARPES) is the most general tool to probe band structure, electronic interactions or spectral function mapping.
- Broad applications: surfaces, thin films, bulk materials, superconductors, magnetic/spin systems, complex materials, topological insulators, graphene based materials, charge density wave materials, low-dimensional systems, artificial stacks, device configurations, etc.



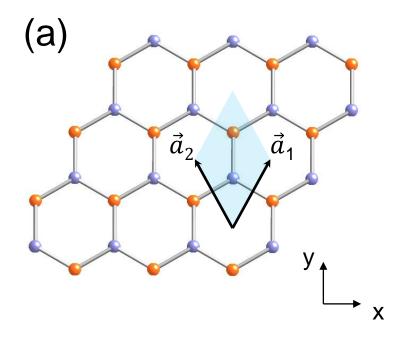
Example: the electronic structure of graphene

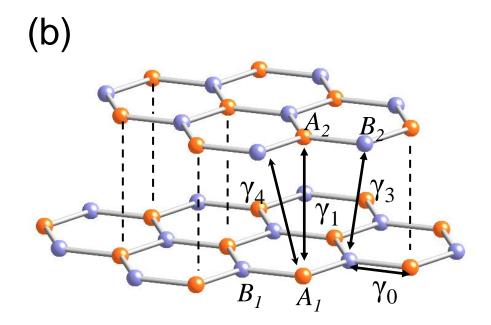






The unit cell of graphene







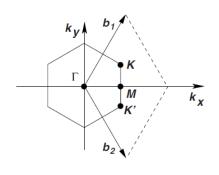
SWMc Hamiltonian of bilayer graphene

$$H(\vec{k}) = \begin{pmatrix} E_0 + \Delta & \gamma_0 f(\vec{k}) & \gamma_1 & \gamma_4 f^*(\vec{k}) \\ \gamma_0 f^*(\vec{k}) & E_0 & \gamma_4 f^*(\vec{k}) & \gamma_3 f(\vec{k}) \\ \gamma_1 & \gamma_4 f(\vec{k}) & E_0 + \Delta & \gamma_0 f^*(\vec{k}) \\ \gamma_4 f(\vec{k}) & \gamma_3 f^*(\vec{k}) & \gamma_0 f(\vec{k}) & E_0 \end{pmatrix}$$
 (b)

$$f(\vec{k}) = \exp(ik_x a_0/2\sqrt{3}) + 2\exp(-ik_x a_0/2\sqrt{3})\cos(k_y/2)$$
$$\vec{k} = (k_x, k_y)$$

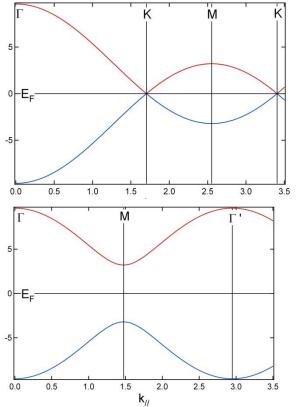


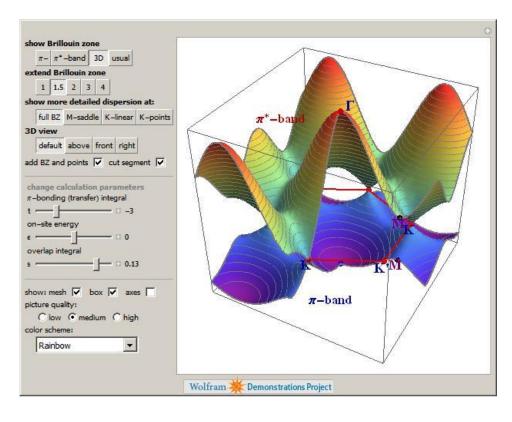
Pure 2D material: graphene

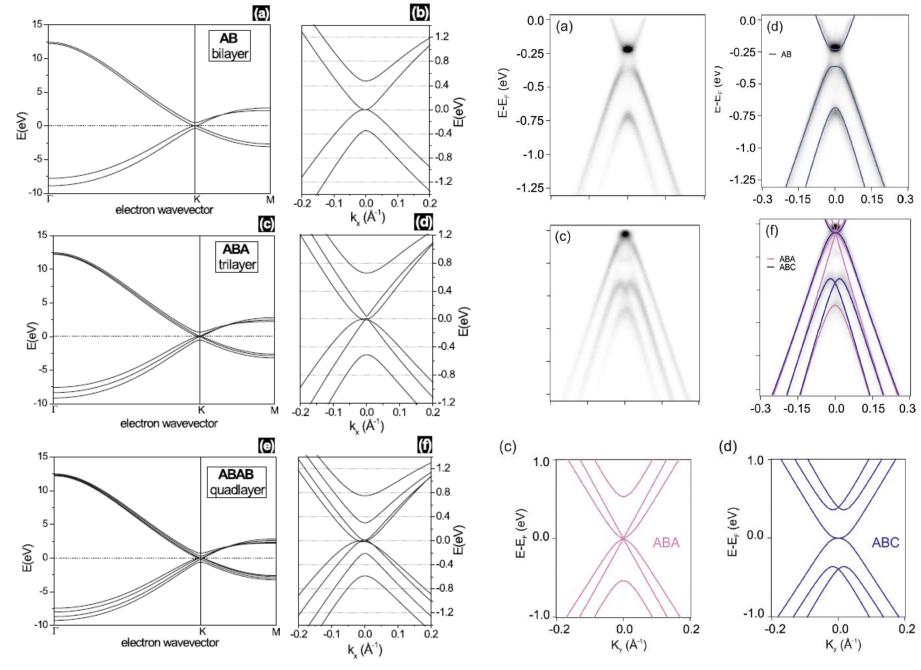


$$\boldsymbol{b}_1 = \frac{2\pi}{3a}(1,\sqrt{3}), \quad \boldsymbol{b}_2 = \frac{2\pi}{3a}(1,-\sqrt{3})$$

$$\mathbf{K} = \left(\frac{2\pi}{3a}, \frac{2\pi}{3\sqrt{3}a}\right), \quad \mathbf{K}' = \left(\frac{2\pi}{3a}, -\frac{2\pi}{3\sqrt{3}a}\right)$$

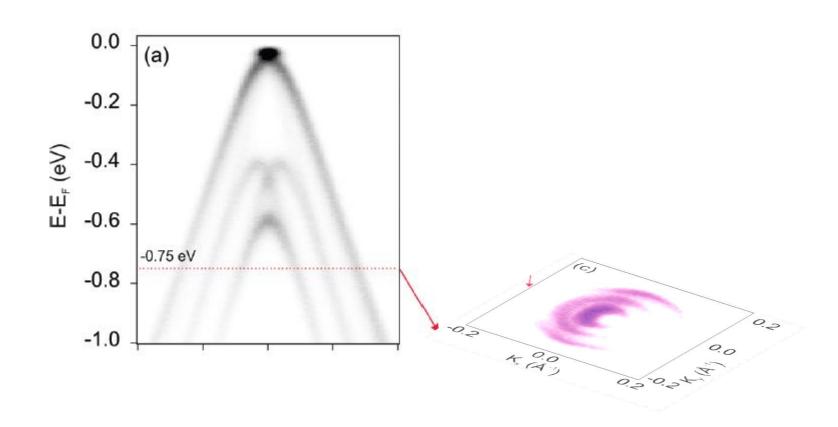






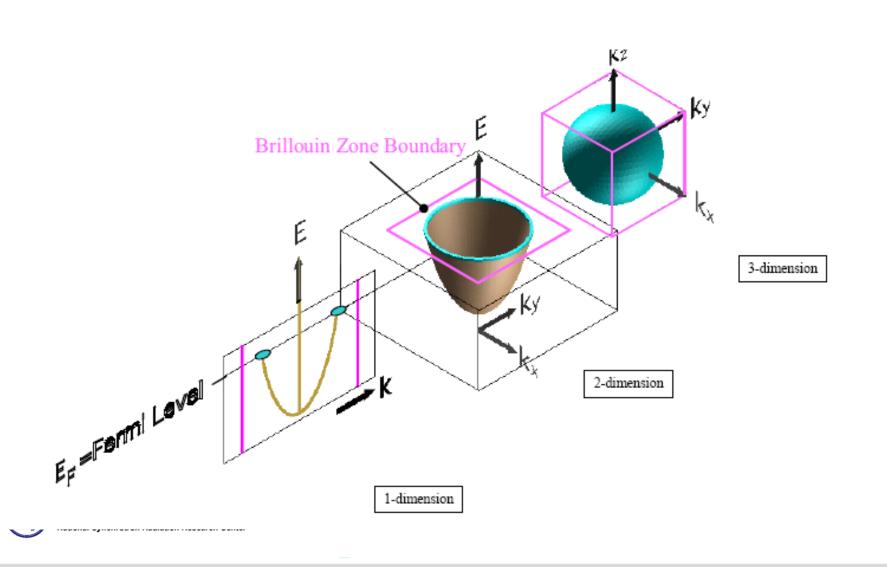
Coletti et al., PRB (2013)

Constant energy mapping





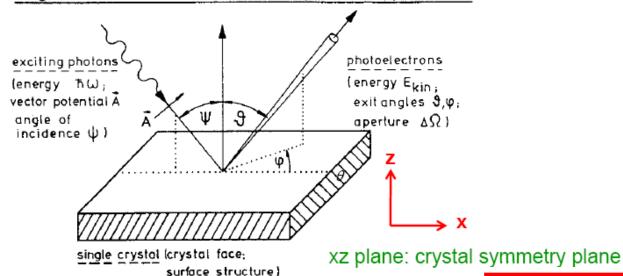
Fermi Surface



How to probe the electronic structure of solids



Angular Resolved Photoemission Spectroscopy(ARPES)



Electron emission angle: θ

Photon incident angle: ψ , s- and p-polarization

$$k = \sqrt{\frac{2m}{\hbar^2} E_k} \cdot \sin \theta$$

$$k_{//}(\text{Å}^{-1}) = 0.5123\sqrt{E_k(eV)} \cdot \sin\theta$$

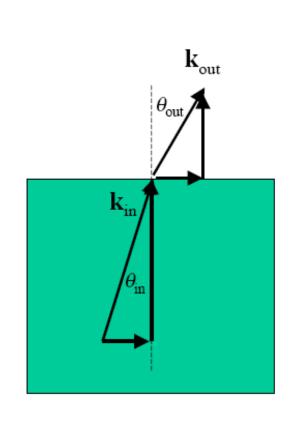
 $k_{||}(inside) = k_{||}(outside)$

Conservation of liner momentum

Important for 3D and 2D band mapping

$$k_{\perp} = 0.5123\sqrt{(E_{kin}\cos^2\theta + V_0)}$$

Conservation of linear momentum parallel to the surface



Kinematic relations

$$k_{out} = \sqrt{\frac{2m}{\hbar^2}} E_{kin}$$

$$k_{in} = \sqrt{\frac{2m}{\hbar^2}} (E_{kin} + V_0)$$

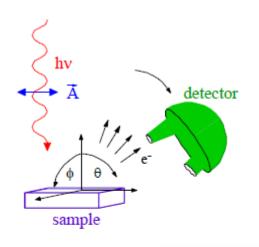
$$k_{out,||} = k_{in,||} \equiv k_{||}$$

"Snell's Law"

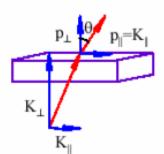
$$k_{\parallel} = \sin \theta_{out} \sqrt{\frac{2m}{\hbar^2} E_{kin}} = \sin \theta_{in} \sqrt{\frac{2m}{\hbar^2} (E_{kin} + V_0)}$$

Critical angle for emission

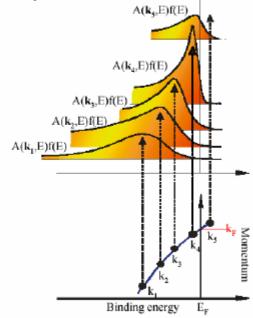
$$\left(\sin\theta_{out}\right)_{\max} = \sqrt{\frac{E_{kin}}{E_{kin} + V_0}}$$



Electron momentum Parallel to the surface is conserved

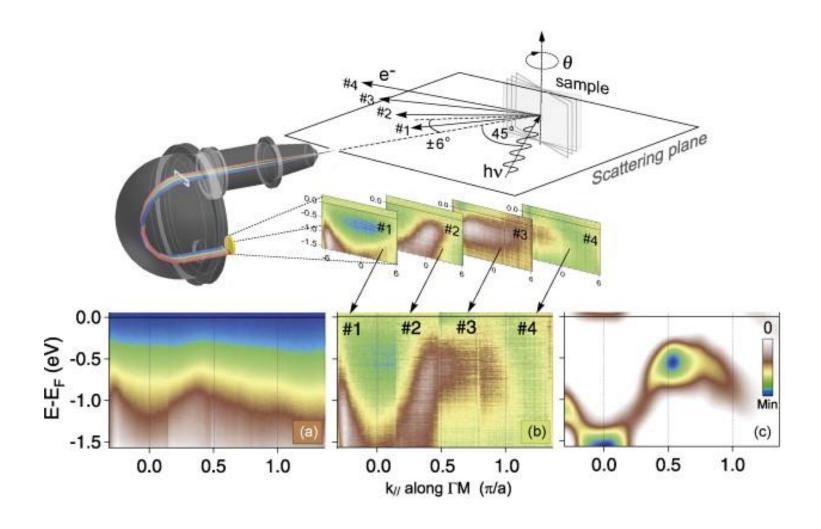


Intensity
$$\propto \sum_{i,f} \left| \left\langle f \middle| \vec{\mathbf{p}} \bullet \vec{\mathbf{A}} \middle| i \right\rangle \right|^2 A(\vec{\mathbf{k}}, E) f(E)$$



- $k_{\perp} = 0.5123\sqrt{(E_{kin}\cos^2\theta + V_0)}$ $k_{//} = 0.5123\sqrt{E_{kin}}\sin\theta$
- 國家同步輻射研究中心 National Synchrotron Radiation Research Center

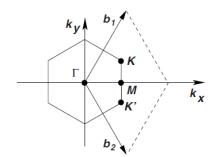
- Low photon energy provides better momentum resolution, but the covering range of BZ is also small.
- We expect to study the electronic structure of solids at VUV region (10 eV~ 100 eV).





$$k_{\perp} = 0.5123\sqrt{(E_{kin}\cos^2\theta + V_0)}$$

 $k_{//} = 0.5123\sqrt{E_{kin}}\sin\theta$



Lattice constant: Graphene: 2.46 Å Cu(111): 2.08 Å

 $MoS_2 : 3.12 \text{ Å}$

✓ Assume the work function is 4.3 eV , please estimate the largest covering range of BZ at the Fermi level at 6 eV, 21.2 eV, 50 eV, 100 eV and 500 eV photon

Answer: 0.67 Å⁻¹, 2.11 Å⁻¹, 3.46 Å⁻¹, 5.01 Å⁻¹, 11.4 Å⁻¹

✓ The angle between the incident beam and spectrometer is 50 degree, please estimate the covering range of BZ at 6 eV, 21.2 eV, 50 eV, 100 eV and 500 eV photon energy.

Answer: 0.51 Å⁻¹, 1.61 Å⁻¹, 2.65 Å⁻¹, 3.83 Å⁻¹, 8.45 Å⁻¹

✓ The BZ in single layer graphene, the magnitude of ΓK is 1.703 Å⁻¹. If you plan to probe the band structure of graphene near the K-point, what are the required angle between the surface normal and spectrometer at 6 eV, 21.2 eV, 50 eV, 100 eV and 500 eV photon energy?

Answer: mission impossible, 54 degree, 29.5 degree, 19.9 degree, 8.6 degree



energy.

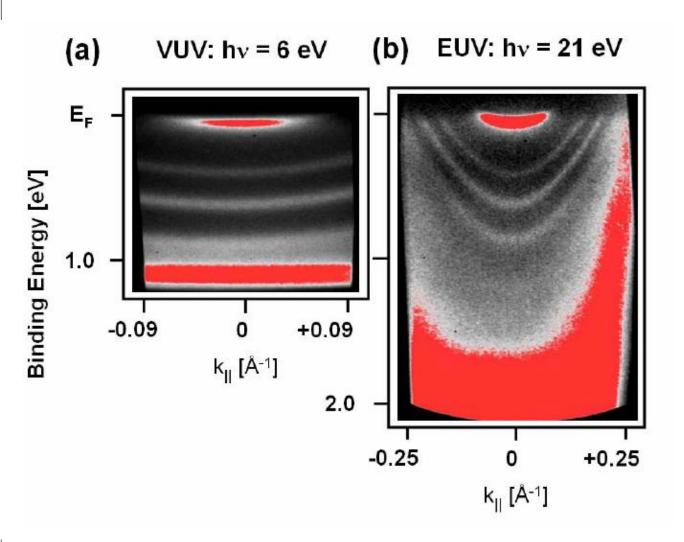
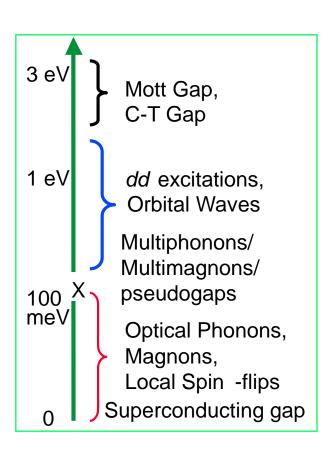


Figure Angle-3. resolved photoemission spectra of the Shockley surface state and a series of quantum well 40 states of MLAg/Cu(111) recorded at photon energies of 6 eV (fourth harmonic of the Ti:sapphire oscillator, 4(a)) and 21.22 eV (He I line of a discharge VUV lamp, 4(b)), respectively.

- > You need to understand the crystal structure of solids.
- ➤ The sample characterization, such as the orientation and crystalline, is quite important before the experiment.
- > XRD, Laue diffraction and LEED are required.



Energy scale and important excitations

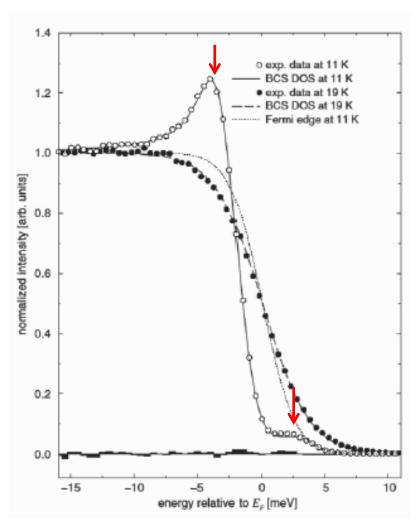


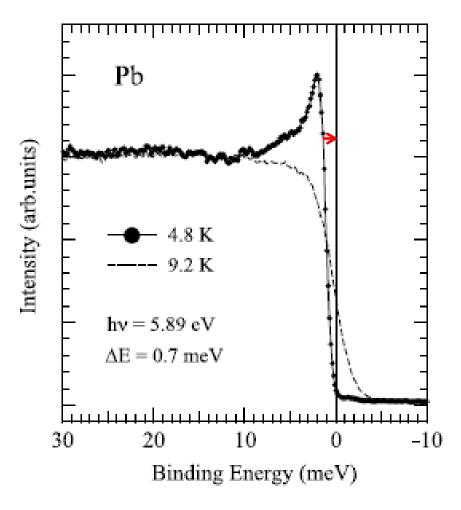
- ➤ Superconducting gap ~ 1 100meV
- ➤Optical Phonons: ~ 40 200 meV
- Magnons: ~ 10 meV 40 meV
- ➤ Pseudogap ~ 30-300 meV
- ➤ Multiphonons and multimagnons ~ 50-500 meV
- ➤ Orbital fluctuations (originated from optically forbidden *d-d* excitations): ~ 100 meV 1.5 eV

Requirement: High Energy Resolution with High Intensity



Superconducting gap





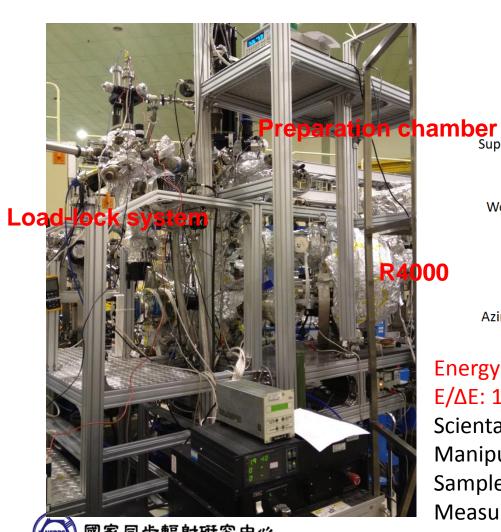


Light sources and terminology

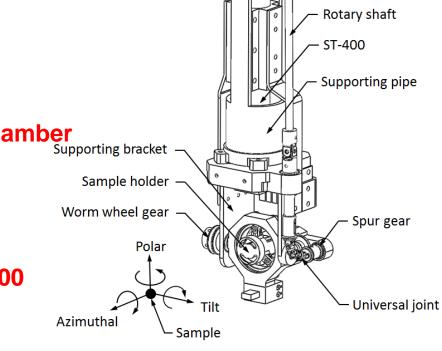
- Ultraviolet Photoemission Spectroscopy (UPS)
 - UV He lamp (21.2 eV, 40.8 eV)
 - Laser: 6 eV (BBO), 8 eV (KBBF), 11 eV (gas cell) or HHG (High harmonic generation)
 - Valence band PES, direct electronic state info.
- X-ray Photoemission Spectroscopy (XPS)
 (Electron Spectroscopy for Chemical Analysis) (ESCA)
 - X-ray gun (Al: 1486.6 eV, Mg: 1253.6 eV)
 - core level PE, indirect electronic state info
 - chemical analysis
- Synchrotron radiation
 - continuous tunable wavelength
 - valance band and core level



Current status of ARPES end station at TLS



National Synchrotron Radiation Research Center



Energy range: 5 eV~120 eV

 $E/\Delta E$: 100,000 at 16 eV and 64 eV

Scienta R4000 analyzer

Manipulator: 6-axis motorized manipulator

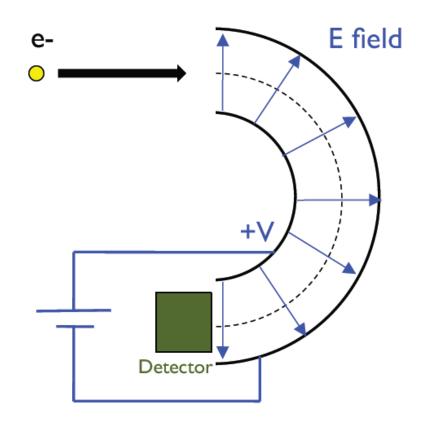
Sample Preparation: in-situ cleave, thin film growth

Measurement temperature range: 10 K~ 350 K

Base pressure : $4.5x10^{-11}$ torr

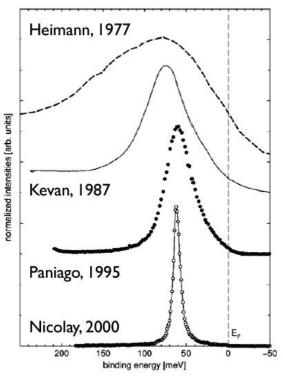
Basic principles of electron spectrometers / analyzers

- typical energy resolution ~ 0.1 to 0.01 eV.
 Best systems are ~ 0.001 eV.
- most electron analyzers operate using electrostatic optics (magnetic fields harder to control)
- detectors are typically channel plates (electron multipliers) with a CCD or current pulse output
- detecting & manipulating electrons is relatively easy



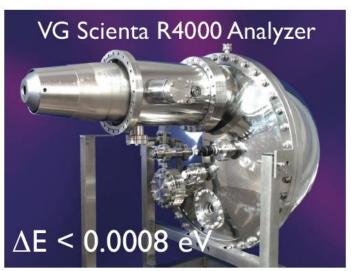
The state-of-the-art in electron spectroscopy

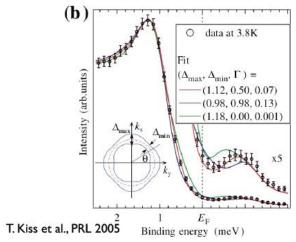
Evolution of instrumental resolution over time



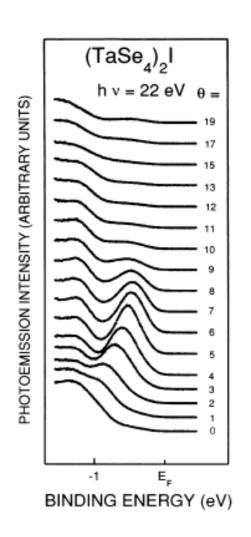
F. Reinert et al., PRB (2001)







Early ARPES experimental result



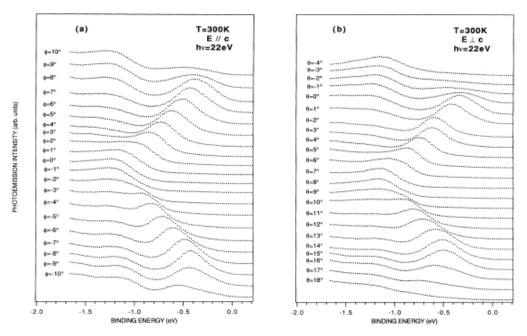


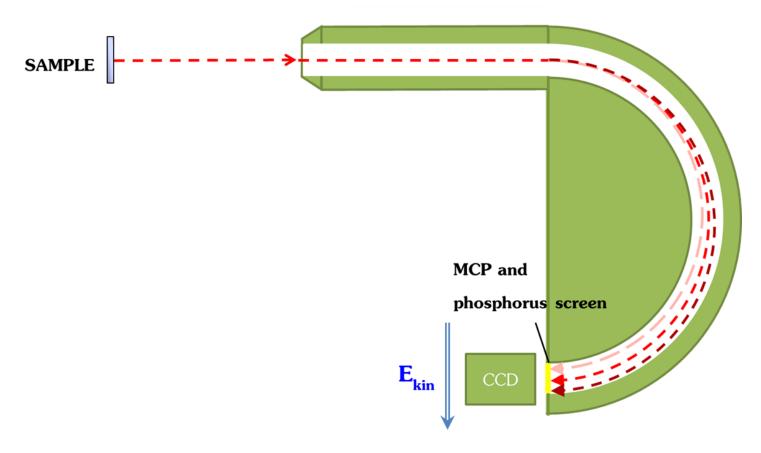
FIG. 1. Angle-resolved photoemission spectra taken using 22-eV photon energy, at room temperature, for photon electric field (a) parallel and (b) perpendicular to the conducting axis. The emission angle is along the conducting axis, with the surface normal defined as 0°.

Now a 2-D detector with \pm 30° and 0.1° angular resolution can be obtained.

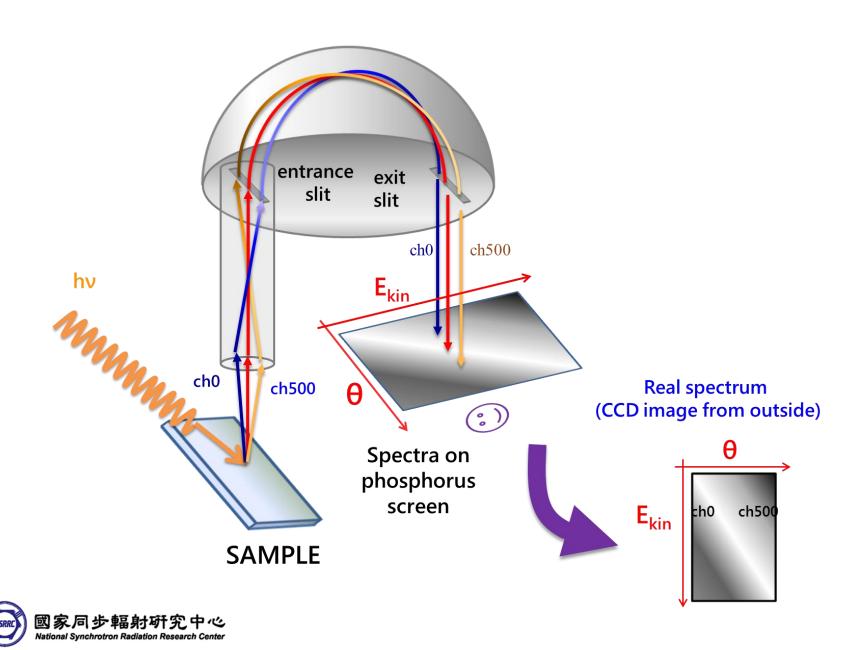


FIG. 1. A series of high-energy-resolution angle-resolved photoemission spectra, taken along the direction of the sample and for different values of the azimuthal angle.

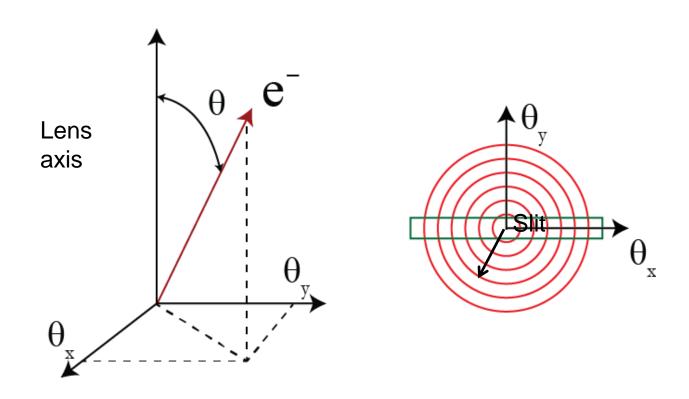
SCIENTA R4000 Side View







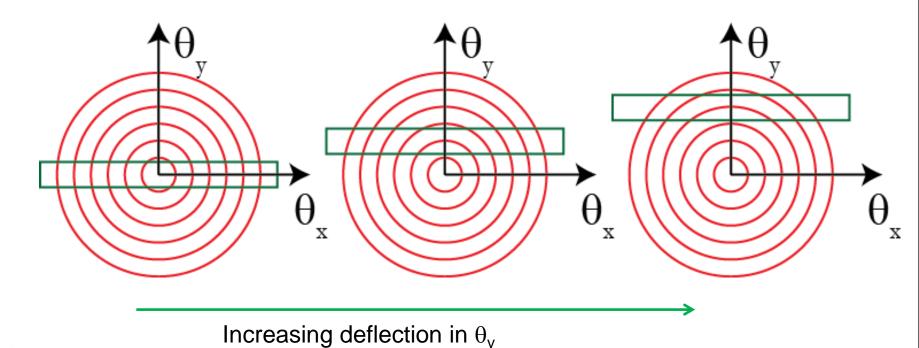
- Angle-resolved spectrometers collects electrons as a function of kinetic energy and emission angle
- Due to the slit, only angles along one axis (q_x) can be detected simultaneously





Constant energy mapping for ARPES Scan

- Deflection can also be done in θ_{y}
- This enables full cone detection, $0 < \theta < 15^{\circ}$, without sample rotation

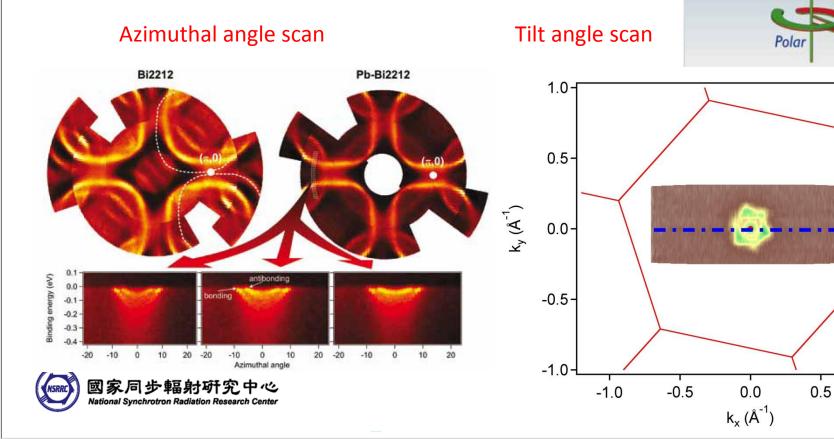




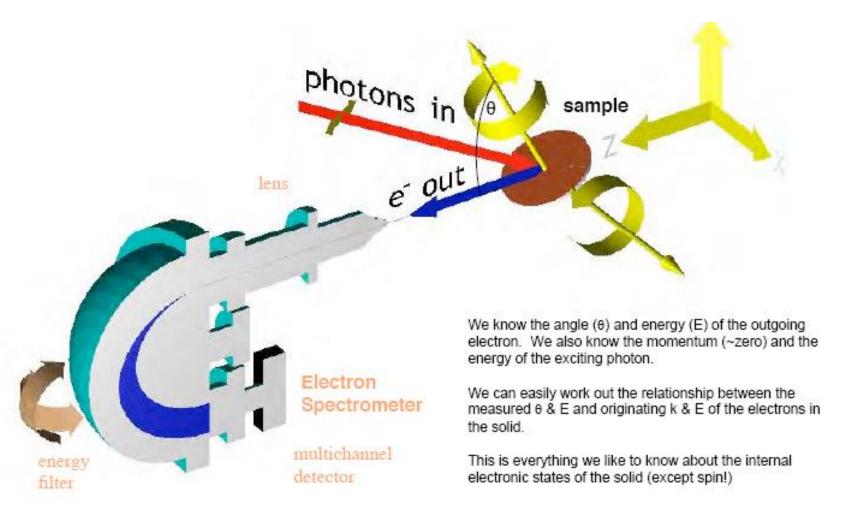
Angle is the soul of ARPES: Band mapping

Azimuthal

1.0



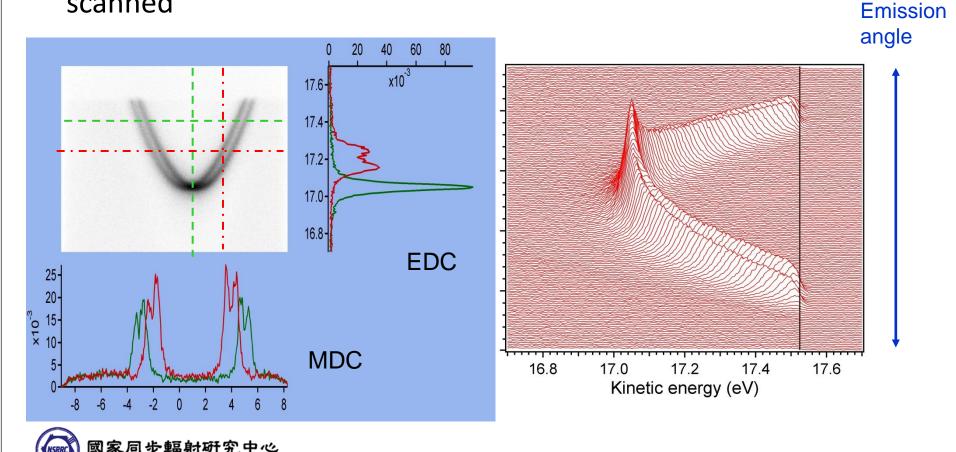
Experimental geometry



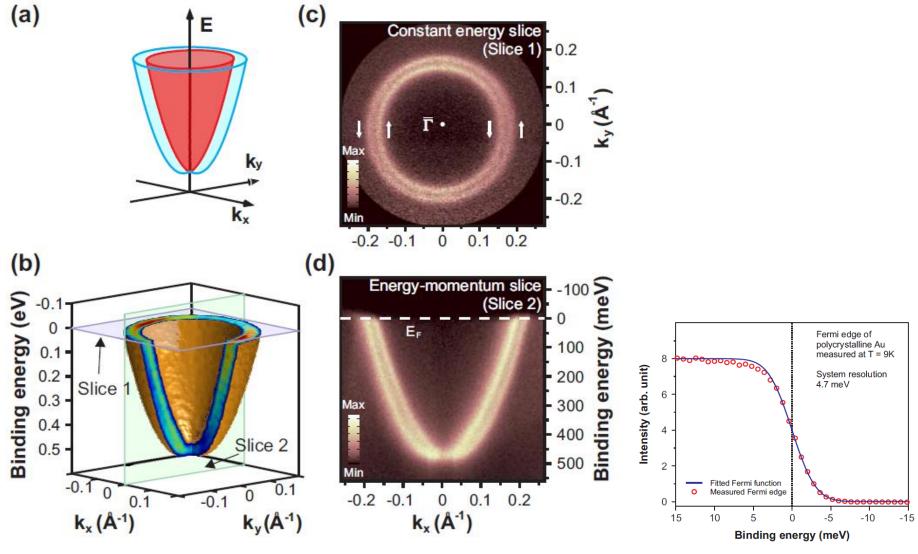


Typical Experimental Result

Accumulate spectra of Rashba effect on Au(111) as the angle is scanned



Surface state of Au(111)

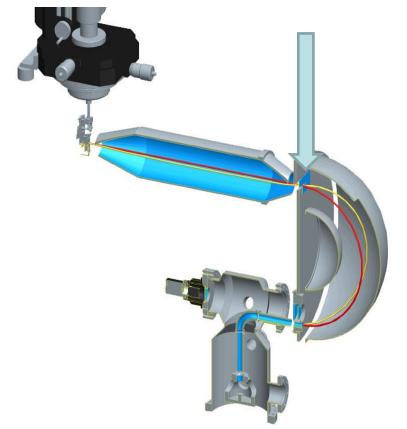


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D. Malterre, CORPES05

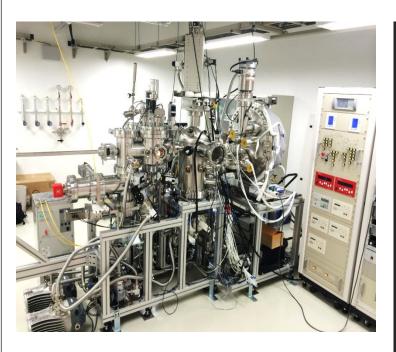
Deflector analyser

- With the deflector analyser, the electron trajectories can be deflected, to change the range of emission angles that reaches the detector
- Deflection can be done in q_x and in q_y .



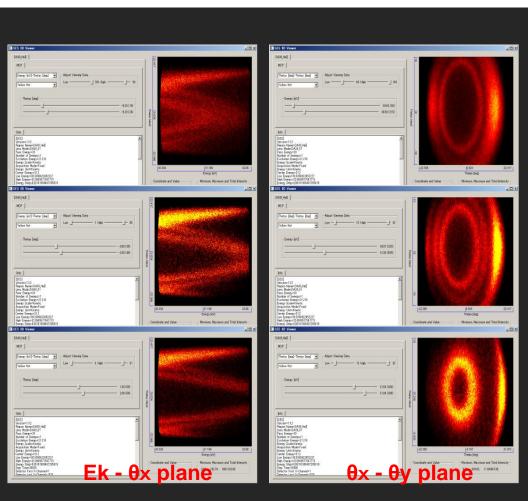


Graphite



Data courtesy: Dr. Yamane, IMS





Electron Escape Depth: Surface Sensitivity

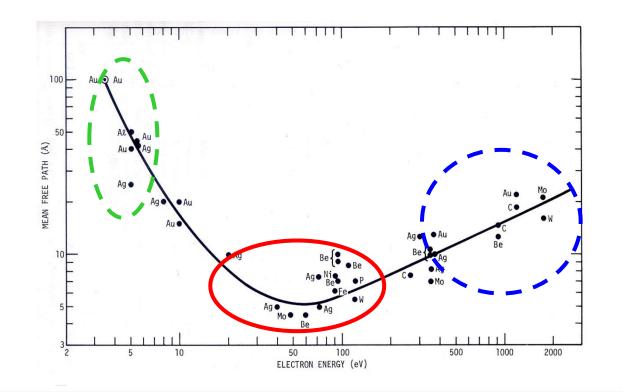
Why are electrons so useful as probes of surfaces?

Minimum due to electron-electron scattering, mainly plasmons

PES is a surface sensitive technique! (requires UHV) High energy photoemission: several keV to increase bulk sensitivity

Or

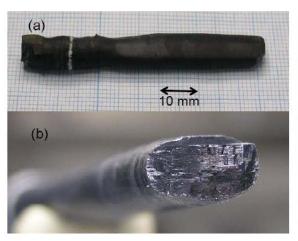
Not so useful for studying bulk properties!!

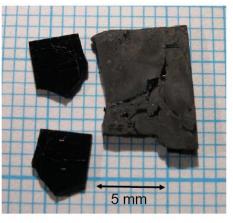




The requirement of ARPES

- UHV environment : better than 1x10⁻¹⁰ Torr
- Single crystals or in-situ growth thin films
- Conductors or semiconductors
- Tunable photon energies





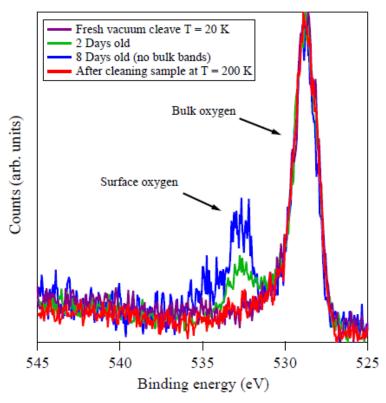
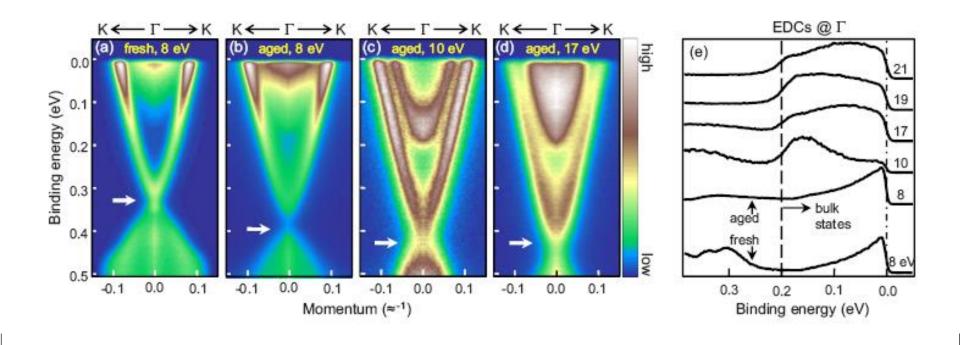


Figure 5.2: (color) The oxygen 1s peaks from Bi2212 at different times after the cleave. A constant background was subtracted from each spectrum to allow direct comparison. The peak derived from bulk oxygen is stable over time, while the surface oxygen peak grows as more oxygen sticks to the cold surface.



HC Hsu, Ph.D. Thesis NTNU(2010) Koralek, U. Colorado Ph.D. Thesis (2007)

Single crystals or *in-situ* growth well-ordered thin films are favorable for ARPES measurement



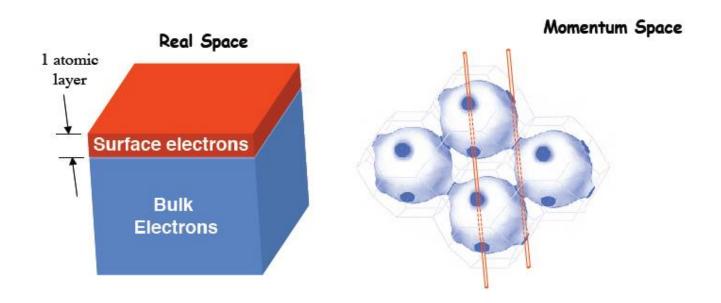
Base pressure: 1x10⁻¹⁰ Torr

In-situ cleaved Bi₂Se₃ single crystal

Using ARPES to study the electronic structure of 2D materials



Surface state

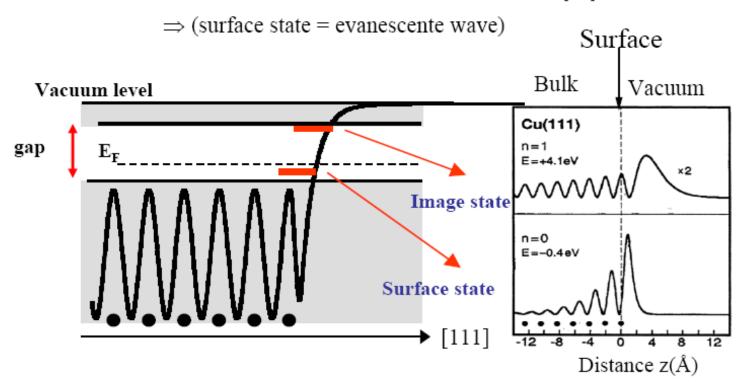


Surface states are highly localized in real space, therefore completely delocalized in k-space along kz.

NO DISPERSION OF SURFACE STATES in kz direction



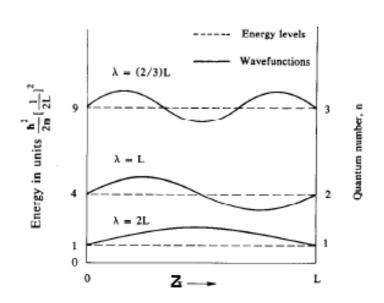
- Surface = Breakdown of the translational symmetry
- \Rightarrow Peculiar solution in the gap with a complexe wave vector $\mathbf{k}_{[111]}$



→localisation of the electronic density at the surface Surf. State is very sensitive to any structural modification



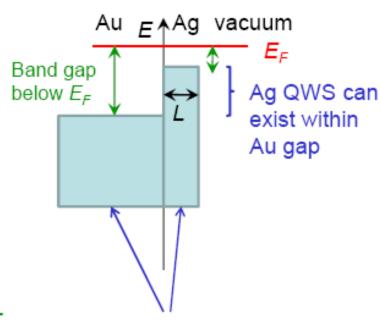
Quantum well states



Quantized discretely along z-direction Energy levels depend on film thickness L

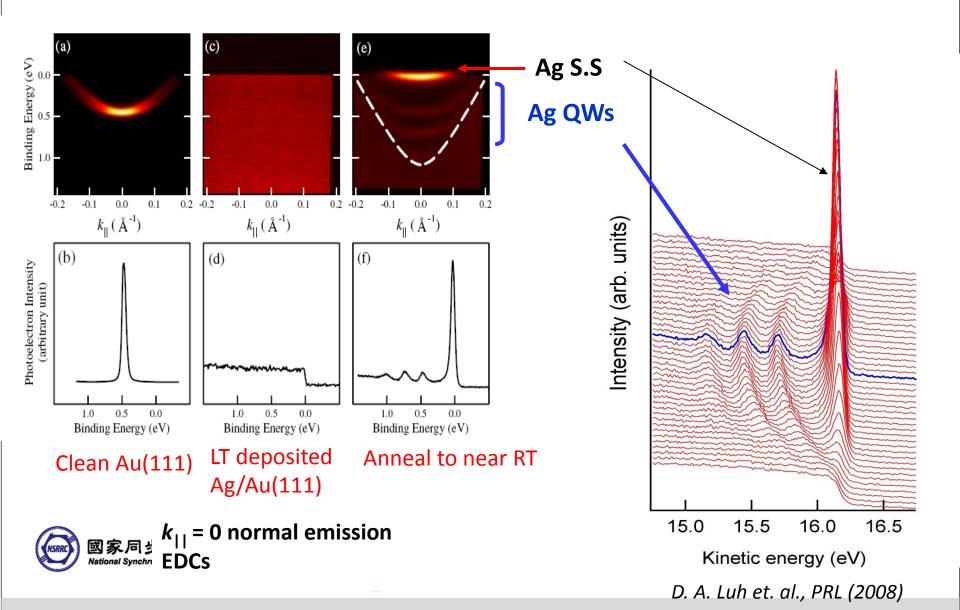
Nearly free electron like in xy-plane

Ag(111) thin films expitaxially grown on Au(111) substrate



Bulk projected bands along ΓL of Au and Ag, respectively

Absolute coverage of thin films: Ag/Au(111) system



Dynamically monitor the thin film growth mechanism

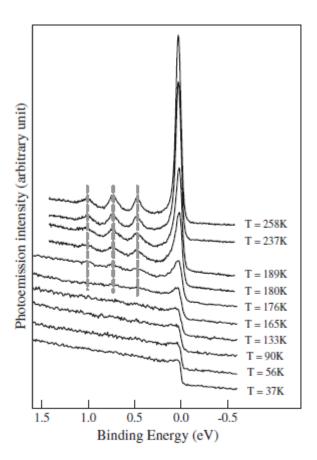
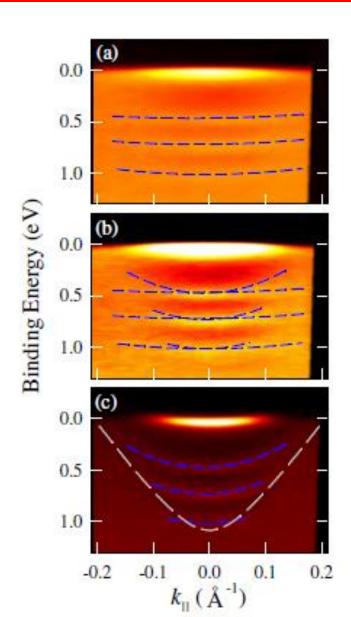
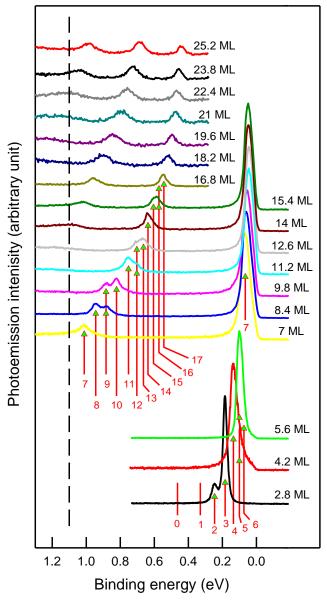


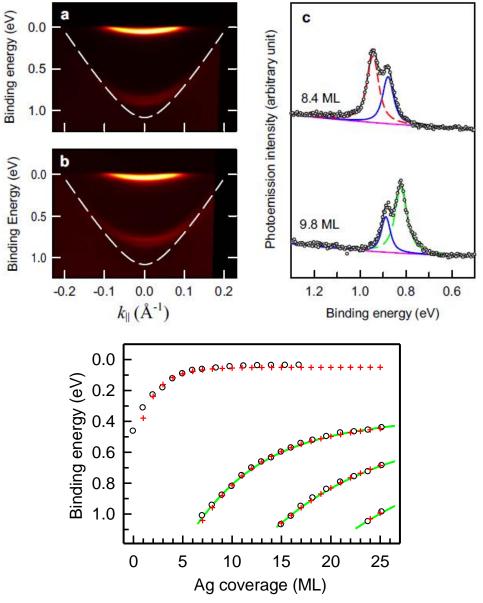
FIG. 2. Energy distribution curves of normal emission from Ag (22 ML) on Au(111) annealed at the indicated temperatures; intensities have been scaled variously for stacking presentation.









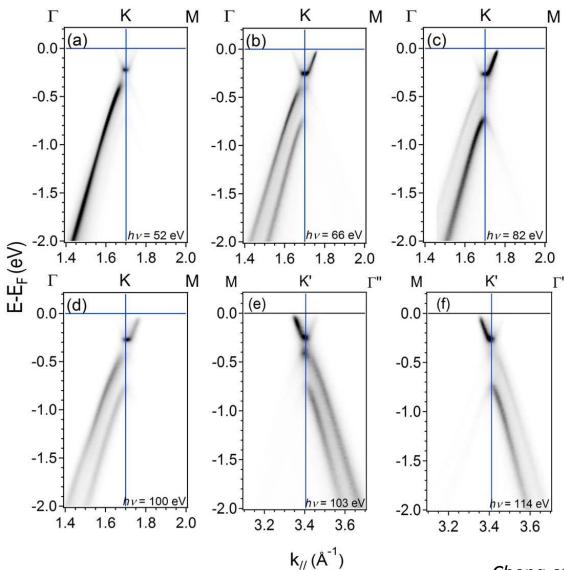


C.-M. Cheng et al., APL (2008)

C.-M. Cheng et al., J. Phys. D: Appl. Phys. (2008)

D.-A. Luh et al., PRB (2008)

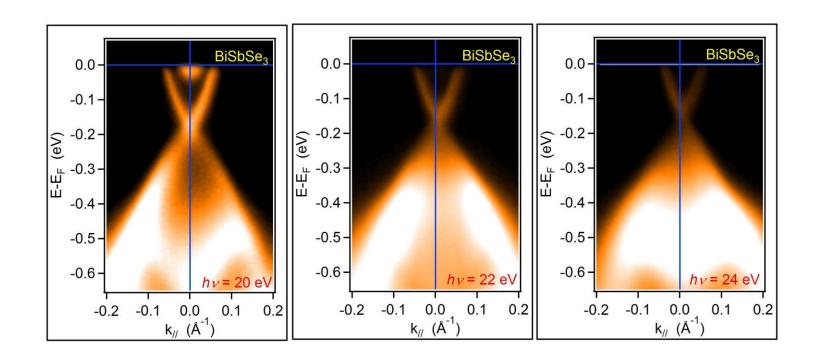
The examination of 2D behavior



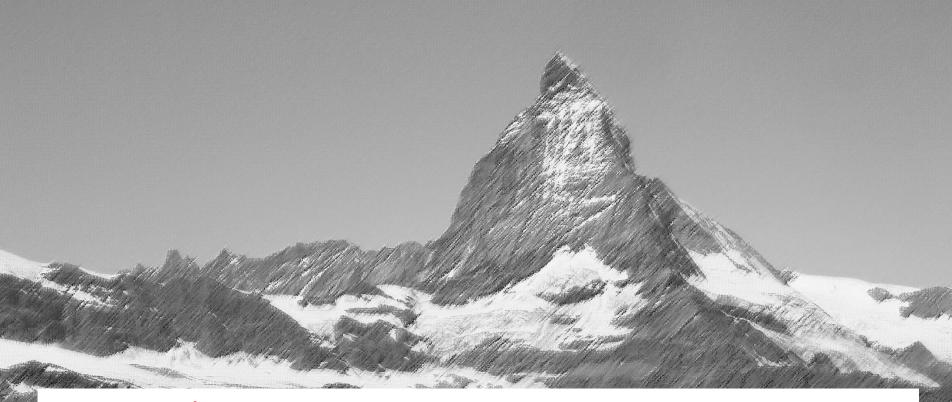


Cheng et al., submitted

The examination of 2D behavior: tuning incident photon energy







2D materials – An Overview

The most well-known 2D material: Graphene

- ✓ First 2D materials studied in detail.
- ✓ Became famous by the works of Novolesov & Geim since 2004.
- ✓ High mobilities (> 100,000 cm2/Vs at RT) raised expectations in future electronic devices.
- ✓ Significant attention for 2D materials beyond graphene

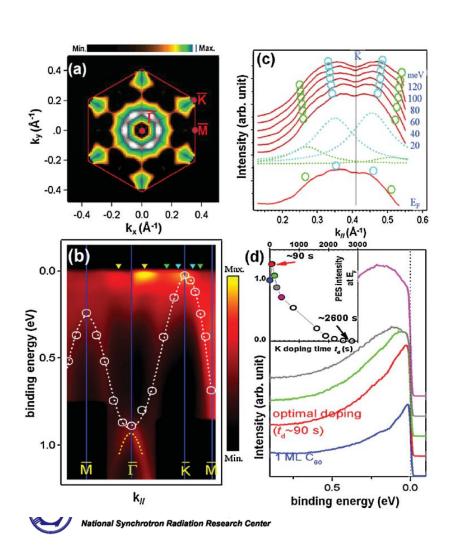
The strictly two-dimensional material

- 70 years ago, Landau argued that strictly 2D crystals were thermodynamically unstable and could not exist
- Before 2004, atomic monolayers only as integral part of 3D structure, grown epitaxially on top of monocrystal
- The discovery of graphene and other free-standing 2D atomic crystals (ex :single layer boron nitride and half-layer BSCCO)

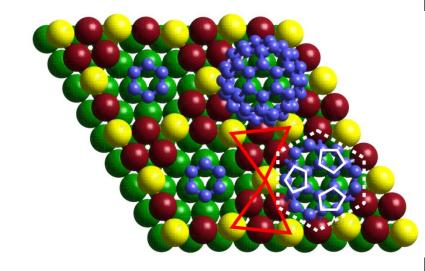
New inroads into low-dimensional physics New surprise to provide highly potential for application



Charge transfer process on ML $C_{60}/Cu(111)$ system

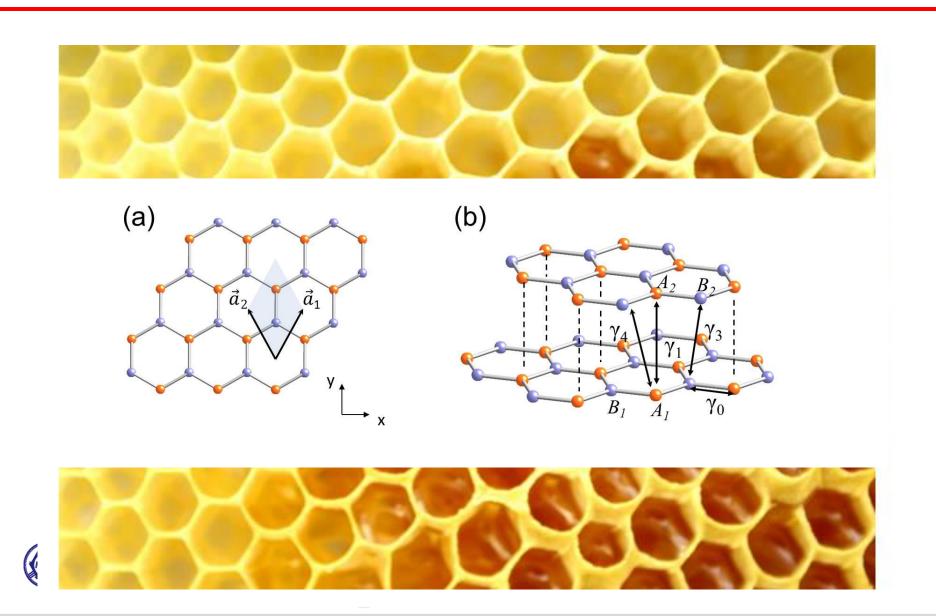


- 1. Large 7-atom vacancies.
- 2. Significant top Cu layer coherent distortion.
- 3. Nearly "optimal" C₆₀³⁻ doping purely by interface reconstruction.

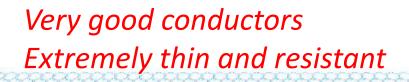


Ref: W.W. Pai et al., PRL 104, 036103 (2010)

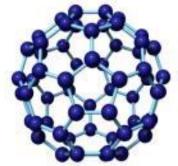
What Is Graphene



What is graphene

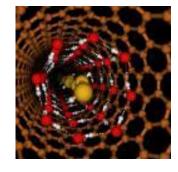






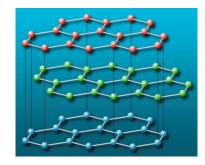
Zero dimensional: fullerenes

Rolled



One dimensional: carbon nanotubes

stacked



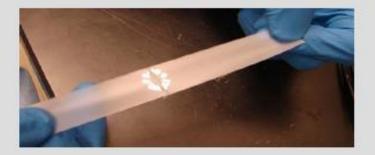
Three dimensional: graphite



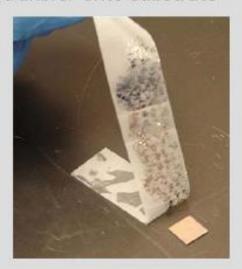
mechanical cleavage

peeling off layers of graphite with a sticky tape





transfer onto substrate





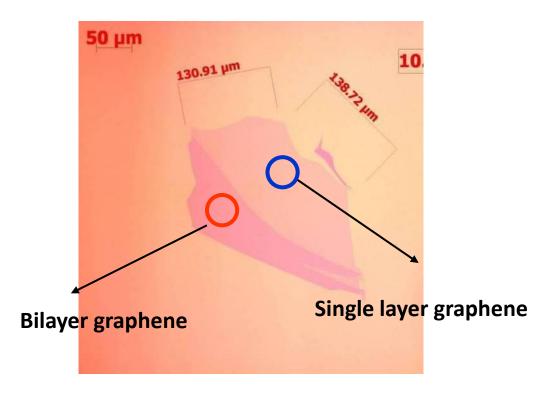
optical microscope image of resulting flakes



How to distinguish the thickness of graphene

SiO₂(200 nm)/Si

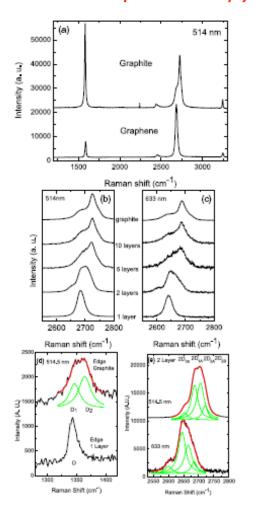
Optical microscopy





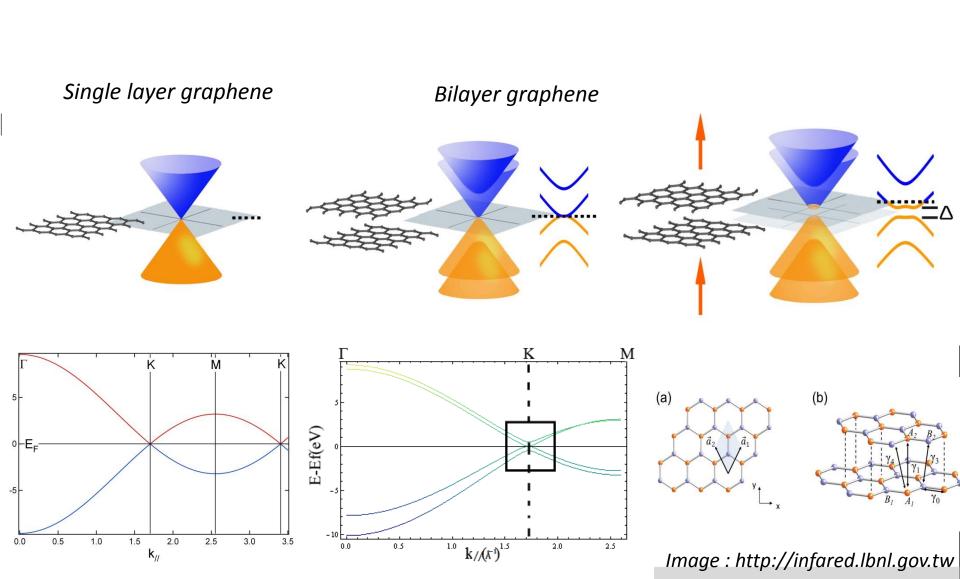
B. özyilmaz , NUS, Singapore

Raman spectroscopy

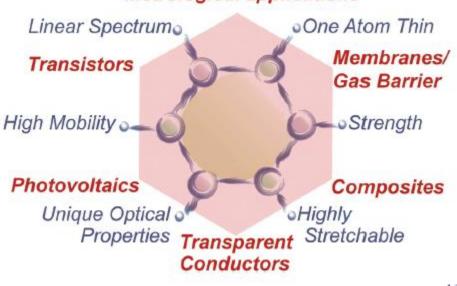


A. Ferrari , PRL 97,187401 (2006)

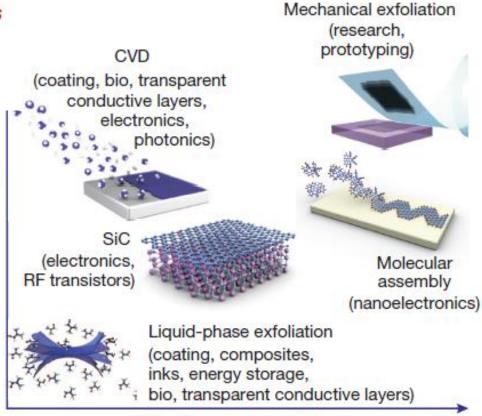
Single layer and bilayer graphene



Metrological applications



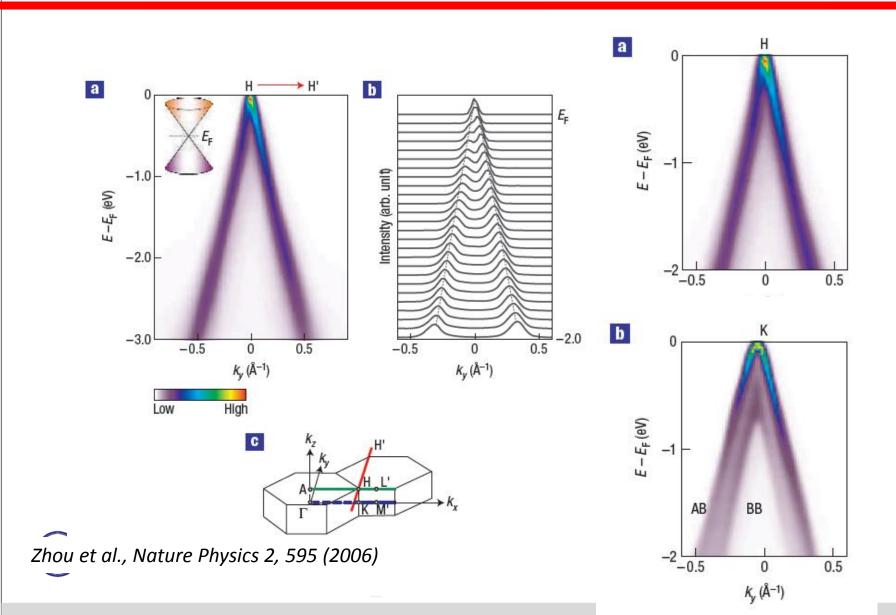
Quality



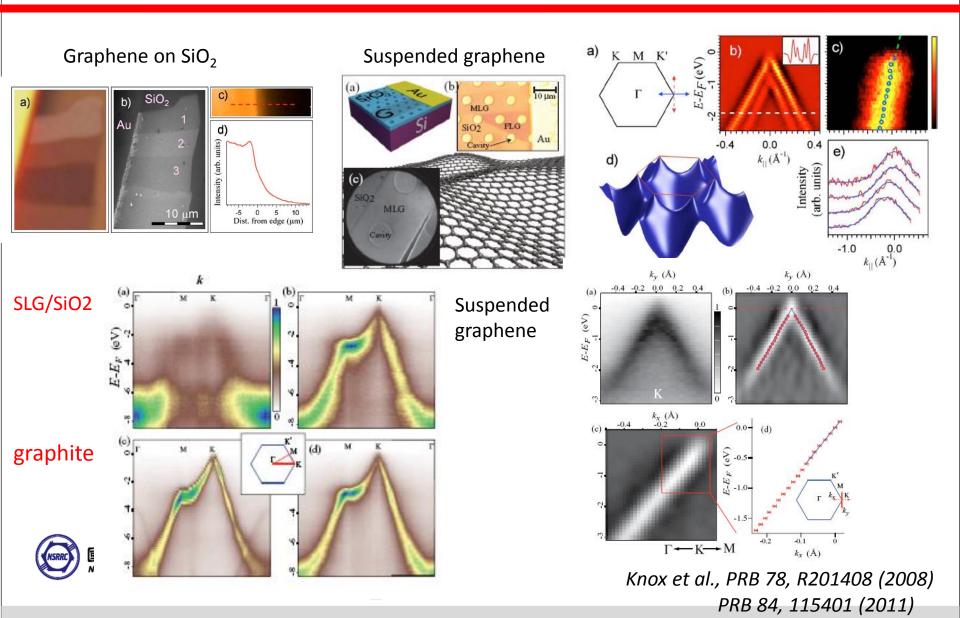


Price (for mass production)

First treament: graphite

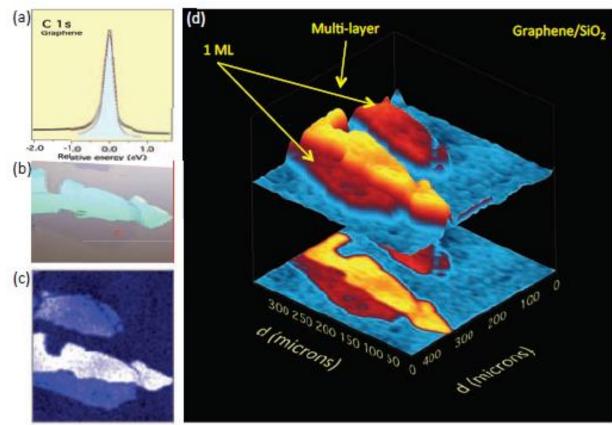


The experiments in graphene on SiO₂ (200nm) and suspended graphene



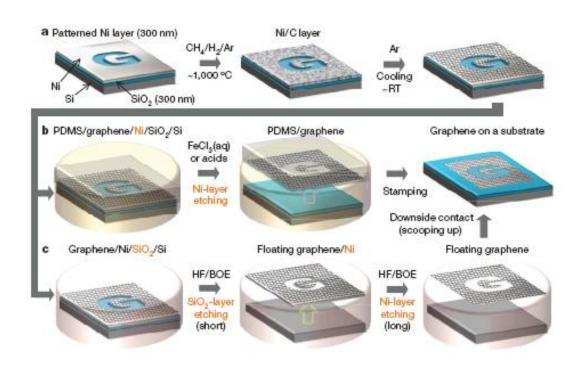
Multi-thickness domains in an exfoliated graphene

Nano-XPS results on exfoliated graphene samples on SiO_2 substrates at the ANTARES beamline, SOLEIL





CVD for large scale graphene film



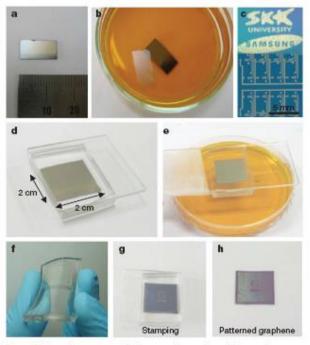
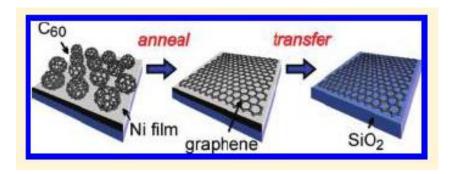
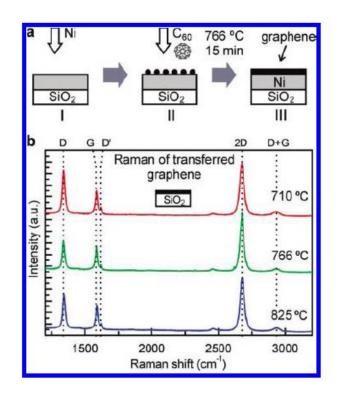
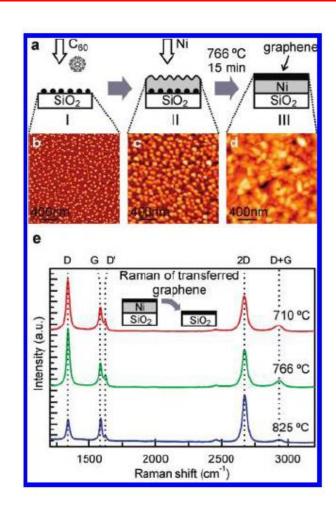


Figure 3 Transfer processes for large-scale graphene films. a, A

Graphene formation by decomposition of C₆₀

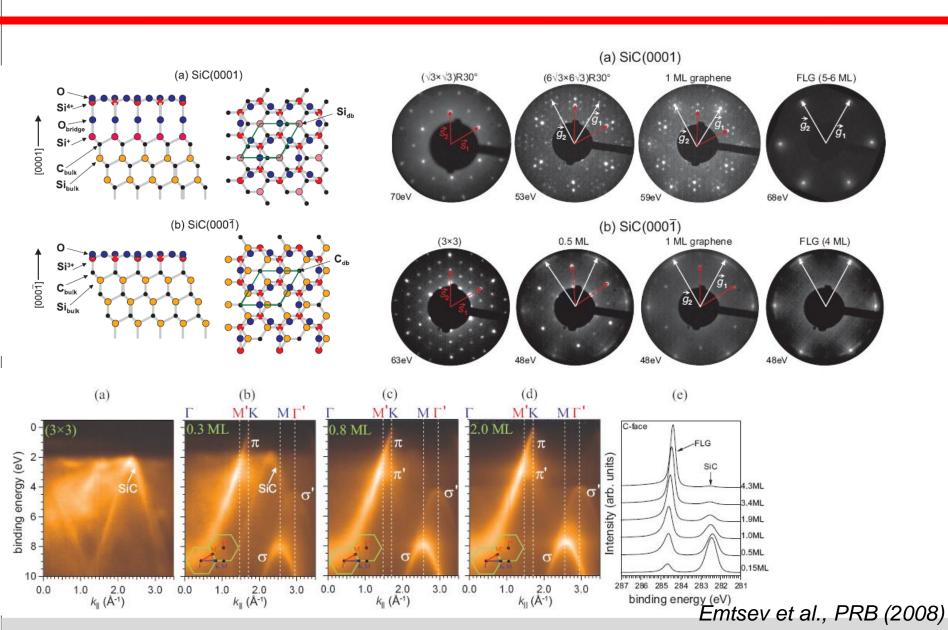




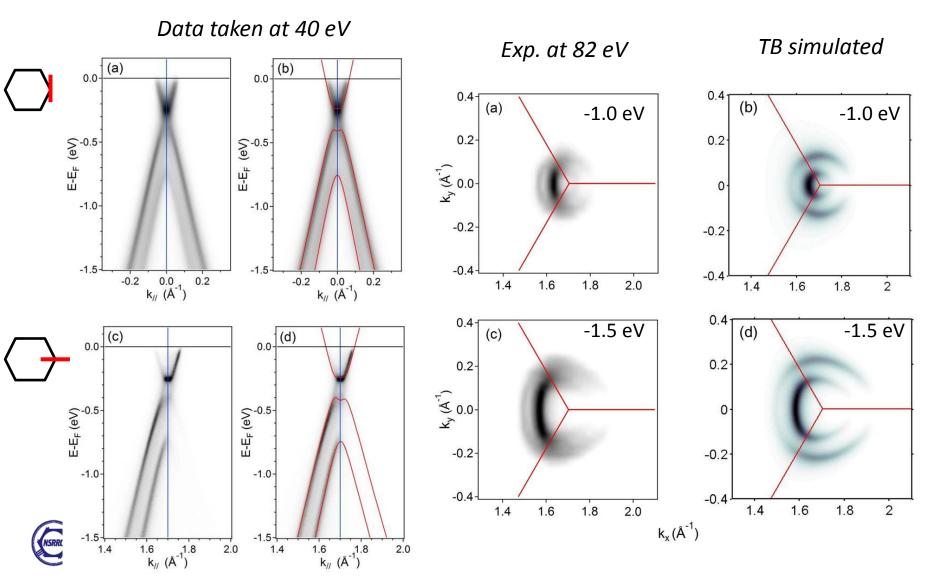




Epitaxial growth graphene on SiC



The electronic structure of bilayer graphene on SiC substrate



Cheng et al., submitted

A intrinsic gap exists or not?

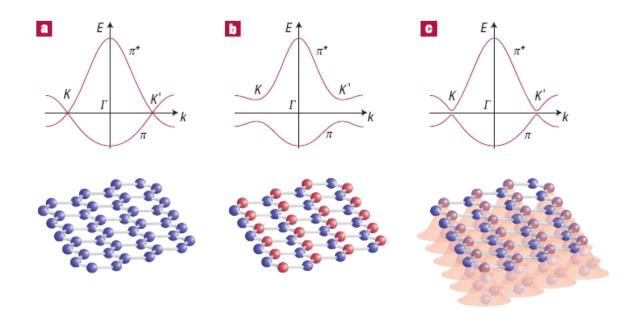
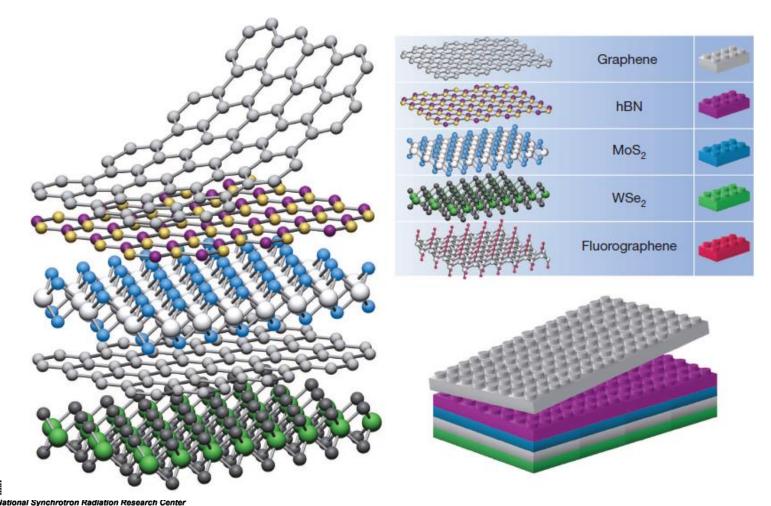


Figure 1 Schematic representation of crystal and electronic band structures (only π -bands are shown). **a**, Free-standing graphene. **b**, Boron-nitride. **c**, Epitaxial graphene. Symmetry between the sublattices in graphene guarantees gapless spectra around K points. This symmetry is broken in boron-nitride (one sublattice consists of boron atoms, another of nitrogen), which immediately opens a gap. In epitaxial graphene, the commensurate underlying potential gives rise to different on-site energies for the two sublattices, which opens a small gap around K points.



A crucial problem to understand the electronic of exfoliated graphene

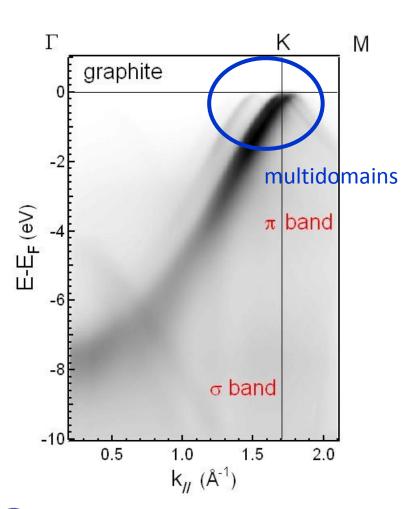
Van der Waals heterostructures

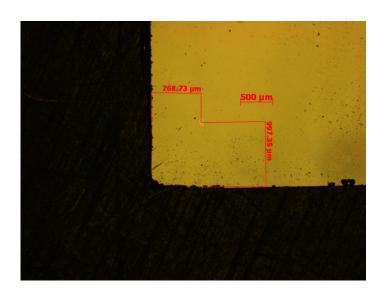


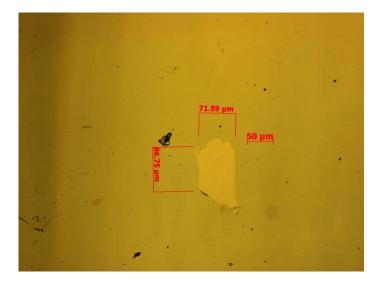
The difficulties for studying the electronic structure of exfoliated graphene

- Insulating substrate induces the strong charging effect.
- Sample size : only several tens microns sample is obtained, but this sample size is quite small for current ARPES beam spot (> 100 μ m) in VUV region. Nano-ARPES provides an advantage to study the electronic structure of exfoliated graphene, but the used photon energy is above 100 eV due to the short focal length of zone plate. It is difficult to make line shape analysis for the many body effect due the poor momentum resolution in high photon energy and the matrix element effect.
- ex-situ sample preparation is not favorable for ARPES experiments.

The band mapping result of Kish graphite

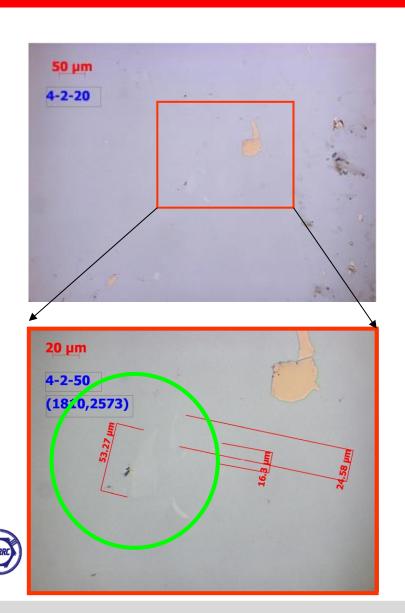


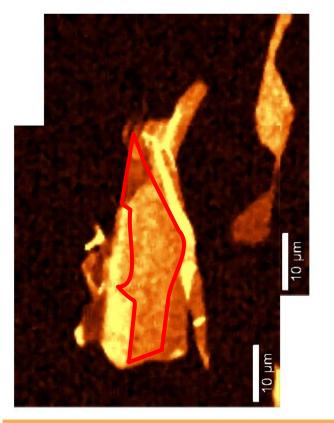






Bilayer graphene / Highly doped Si substrate

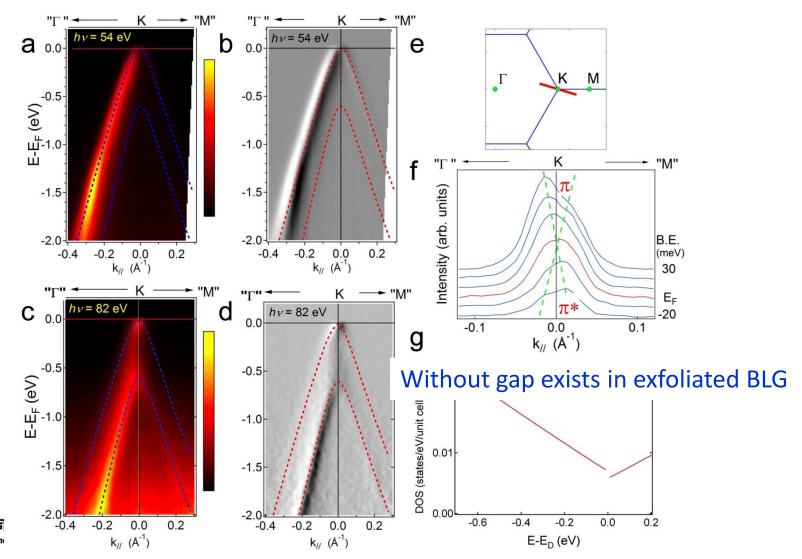




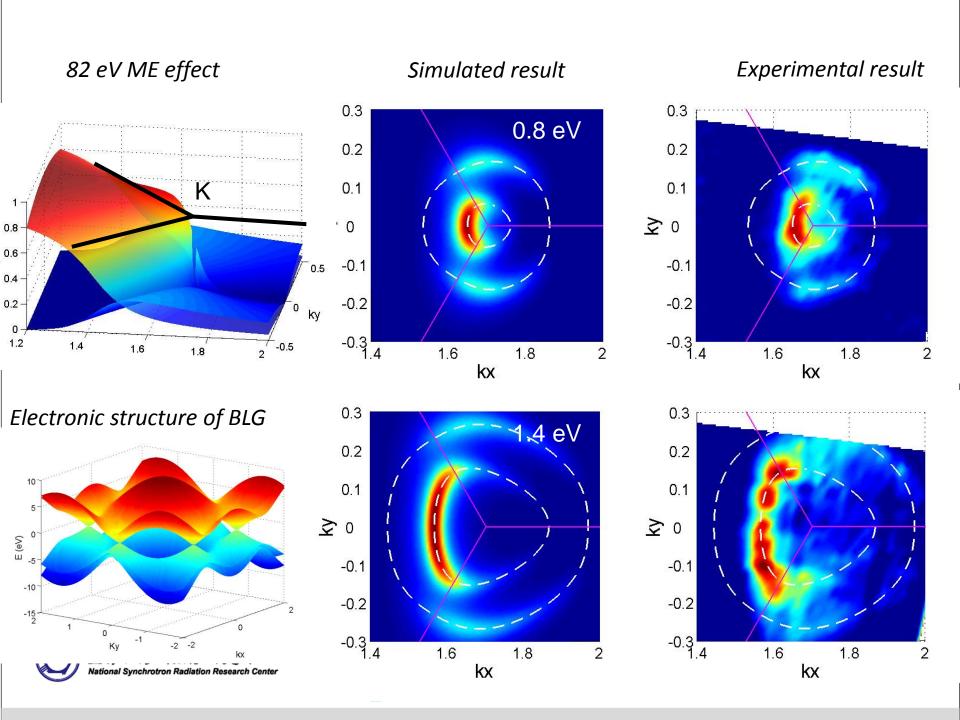
Intensity of G band (overlap of 2 scans showing flake 1 and 3)

Raman result : BLG is the area marked with red color.

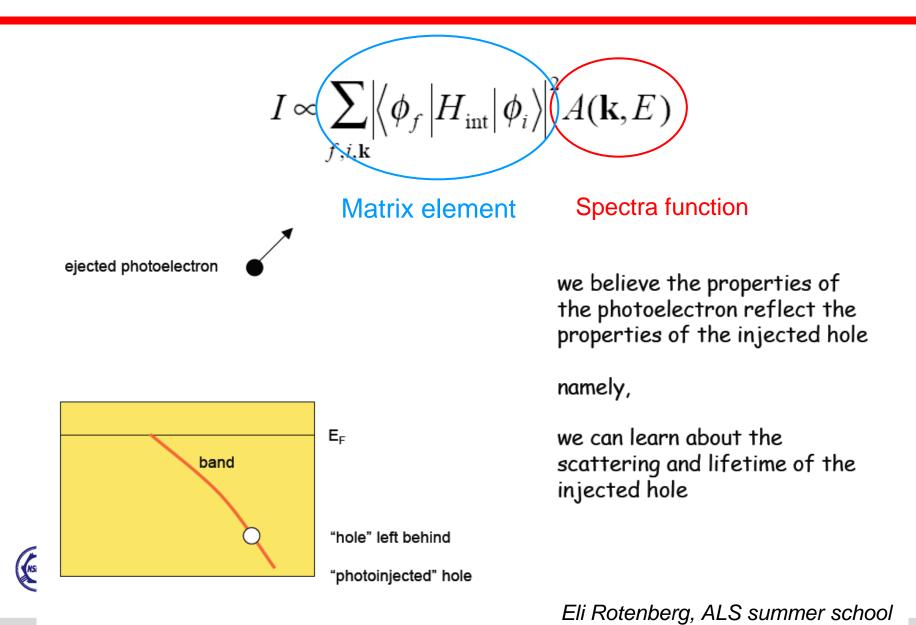
The electronic structure of bilayer graphene



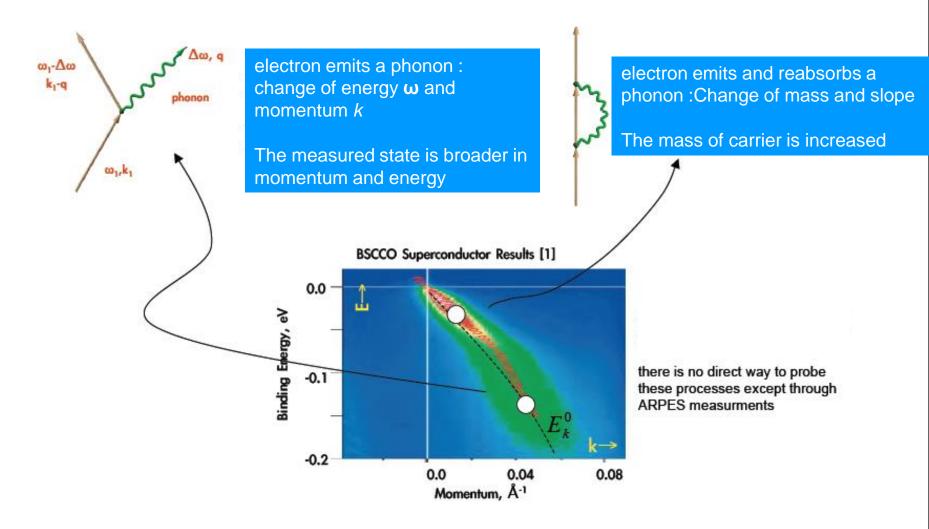




What does ARPES measure



The carriers have a finite lifetime due to absorption and emission of phonons and other excitations



Self energy in photoemission spectra

The quantity determined in ARPES experiments is the single-particle spectral function

$$G(k,\omega) = \frac{1}{\omega - \varepsilon_k - \Sigma(k,\omega)}$$

$$A(k,\omega) = \frac{\operatorname{Im}\Sigma(k,\omega)}{\left[\omega - \varepsilon_k - \operatorname{Re}\Sigma(k,\omega)\right]^2 + \left[\operatorname{Im}\Sigma(k,\omega)\right]^2}$$

$$\Sigma = \text{Re}\,\Sigma + i\,\text{Im}\,\Sigma$$



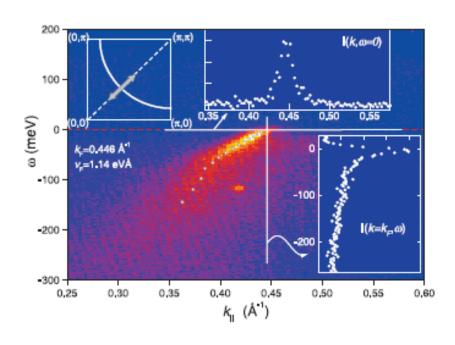
Dispersion:

E-k Relation (Velocity; Effective mass etc.)



Scattering rate (Lifetime)

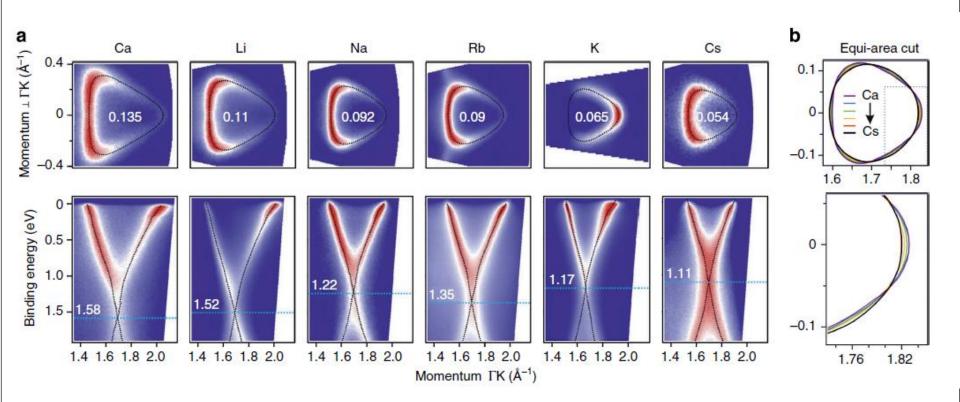
Optimally doped Bi-2212 cuprate



$$\hbar v_k \Delta k = \frac{\hbar v_k}{l} = \left| 2 \operatorname{Im} \Sigma(k, \omega) \right|$$

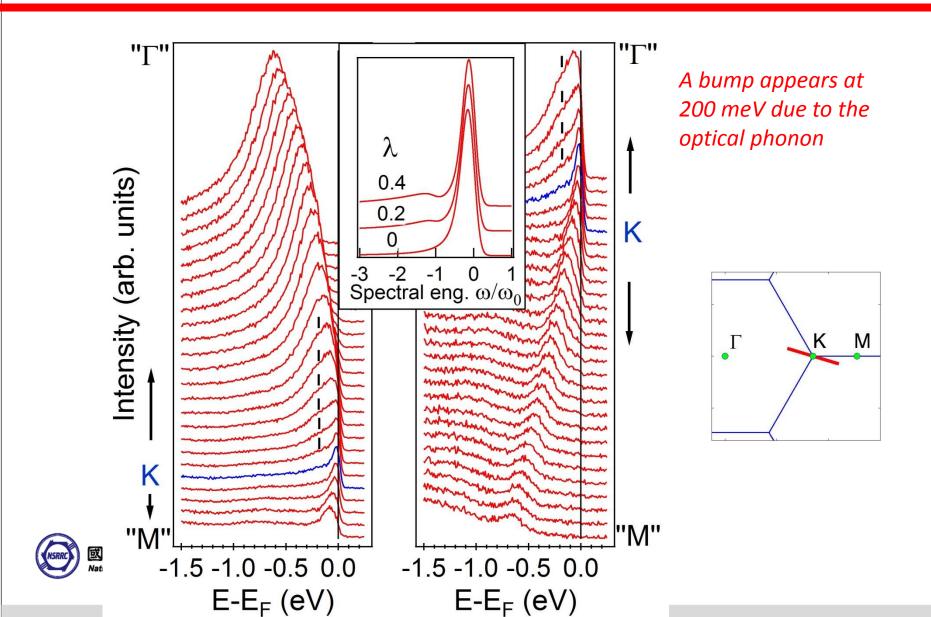
T. Valla et al., Science 285, 2110 (2000)

Electron-phonon interaction in doped graphene

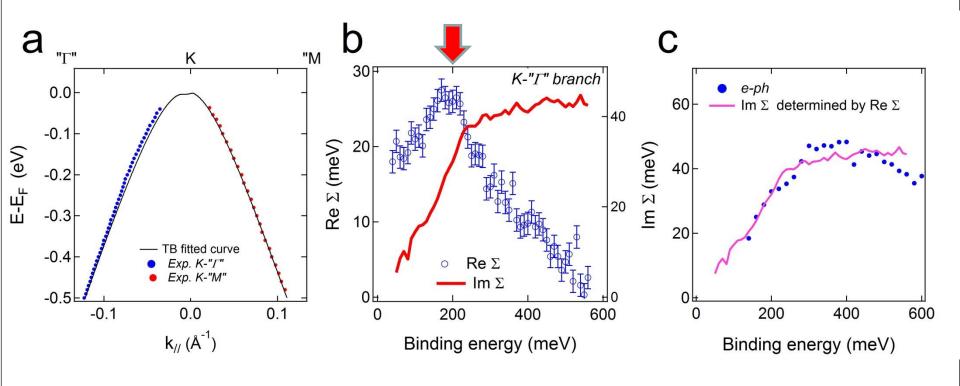


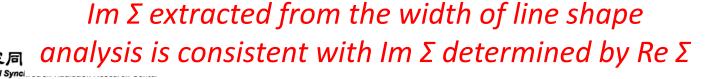


Anisotropic *e-ph* interaction property on K-Γ and K-M branches

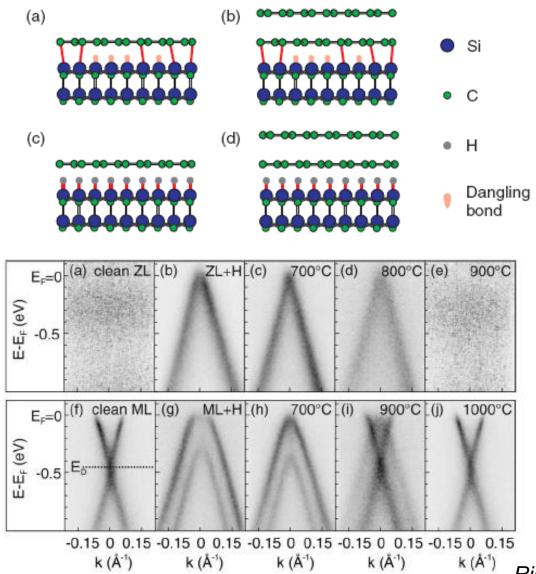


The KK transformation between Re Σ and Im Σ





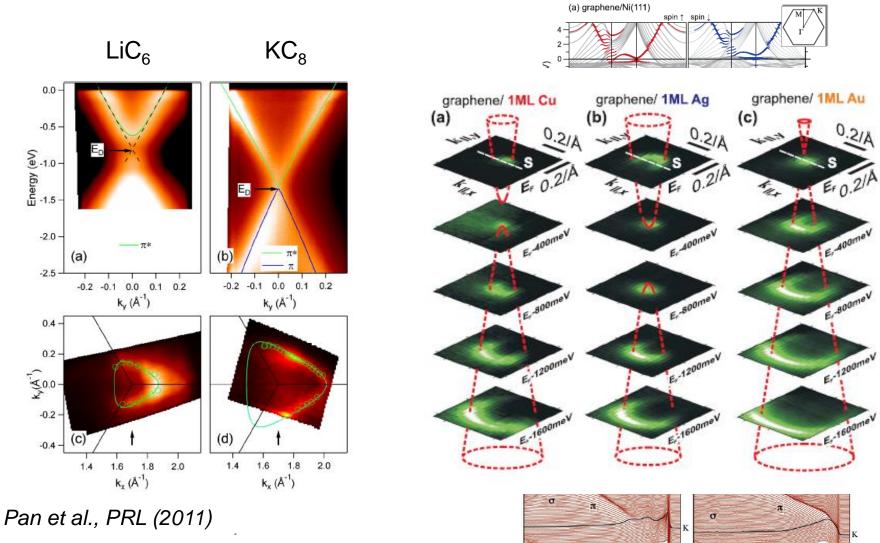
Hydrogen intercalated graphene/SiC





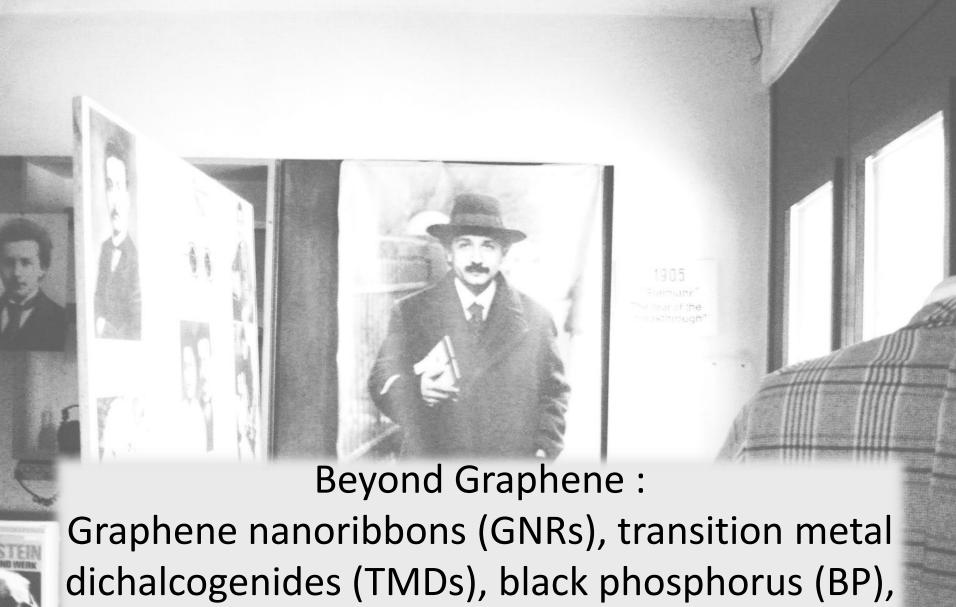
Riedl et al., PRL (2009)

Graphene intercalated compounds (GICs)



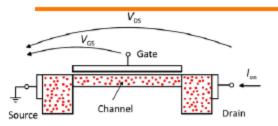
Binding Energy (eV)

Pan et al., PRL (2011)
Voloshina et al., NJP (2011)
Varykhalov et al., PRB (2010)



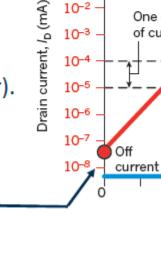
FET Basics – Digital CMOS

On-state



Requirements for logic

- High on-off ratio I_{on}/I_{off} $10^4...10^7$.
- High I_{on} (high speed).
- Low I_{off} (low static power).
- Steep slope in subthreshold, i.e., small SS.

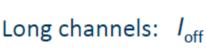


10-1

10-2

10-3

10-4



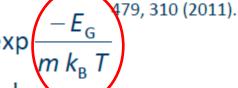


Threshold voltage

1/slope = SS

 $\Delta V_{\rm G} = 80 \text{ mV}$

0.4

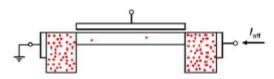


0.8

0.6

Gate voltage, V_G (V)

Off-state



A sizeable gap is mandatory!

0.2

One decade of current



On current

0.8

0.6

0.4

0.2

1.0

Ferain, Nature

2D materials :potential candidates for future applications

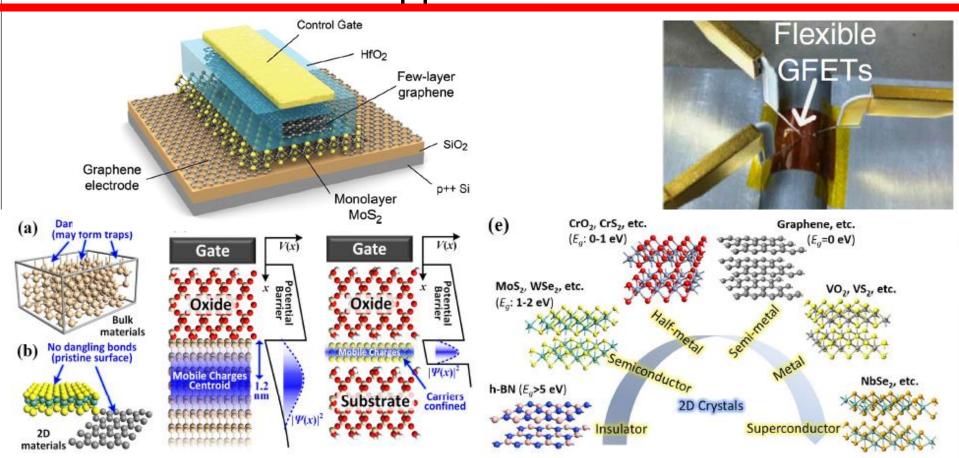


Figure 1. Schematic illustrating advantages of 2D materials: surfaces of (a) 3D and (b) 2D materials. The pristine interfaces (without out-of-plane dangling bonds) of 2D materials help reduce the interface traps. Mobile charge distribution in (c) 3D and (d) 2D crystals used as channel materials. The carrier confinement effect in 2D materials leads to excellent gate electrostatics. (e) Various types of 2D materials from insulator to superconductor. E_g denotes the band gap.

Kang et al., Proc. SPIE (2014)

Graphene family

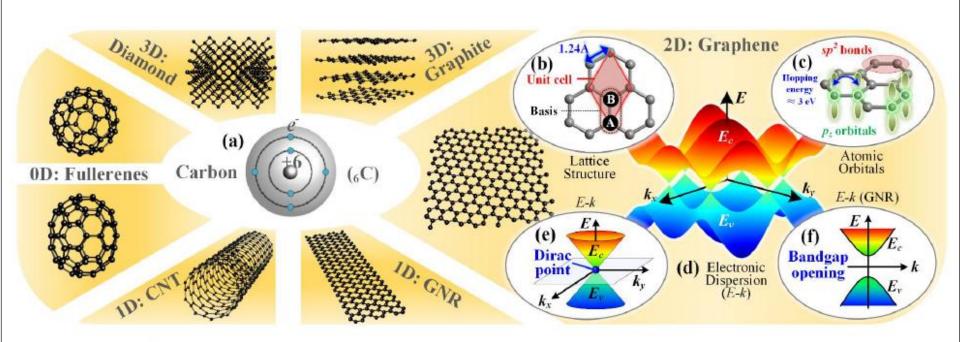
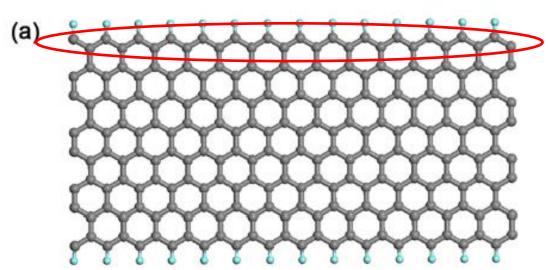


Figure 2. (a) Schematic of carbon atom and carbon allotropes, from 0D to 3D; (b) unit cell, basis and bond length of graphene; (c) atomic orbitals of graphene; (d, e) energy dispersion of graphene, where the energy dispersion is linear for low energies near the six corners (Dirac points) of the two-dimensional hexagonal Brillouin zone. (f) Energy dispersion of a semiconducting GNR, where a bandgap can be engineered by varying the width.

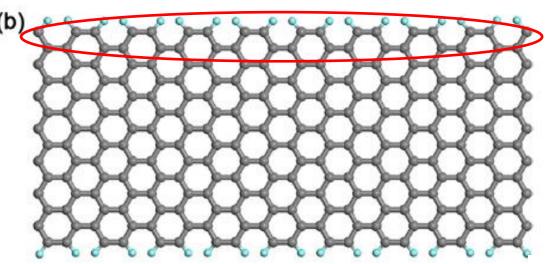


Crystal structure of GNRs



Armchair Graphene Nanoribbons (AGNRs)

TB simulation : semiconducting or metallic depending on the width of AGNRs

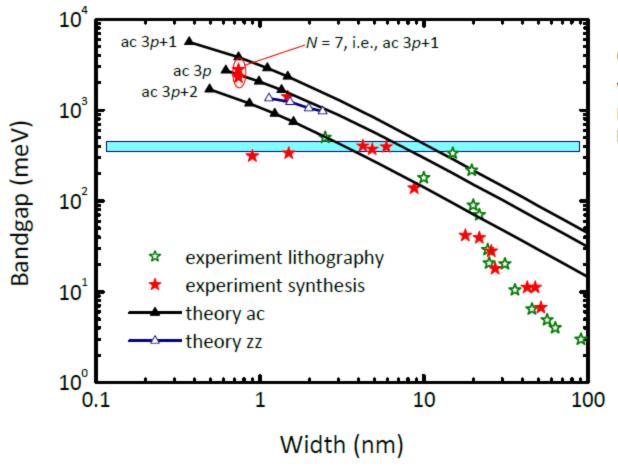


National Synchrotron Radiation Research Center

Zigzag Graphene Nanoribbons (ZGNRs)

TB simulation: metallic for all ZGNRs

H. Terrones et al., Rep. Prog. Phys. (2012)



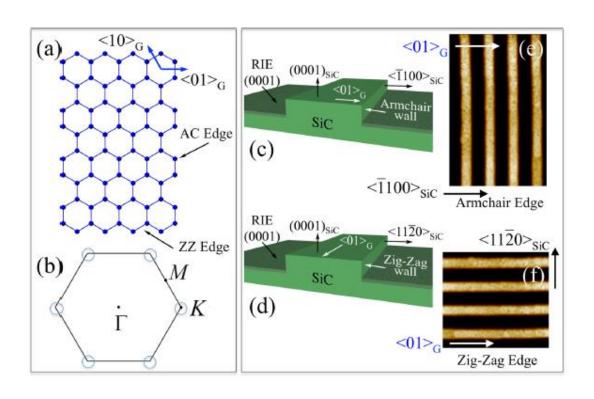
GNR bandgap vs width.

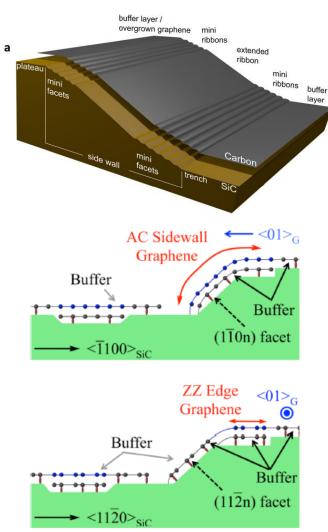
FS, Pezoldt, Granzner, Nanoscale 2015.

The bandgap of GNRs depends strongly on the ribbon width and the edge configuration!



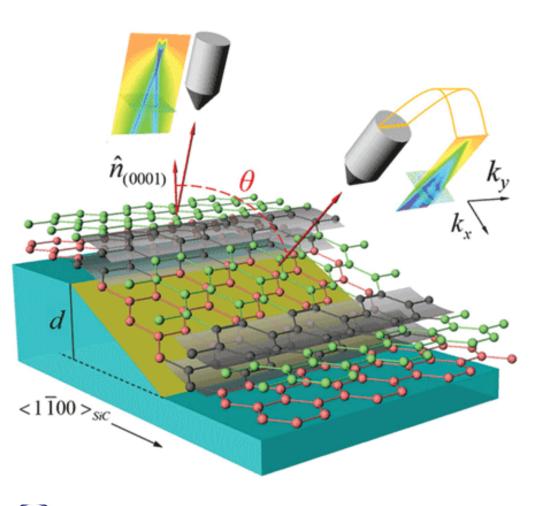
Sample preparation for GNRs

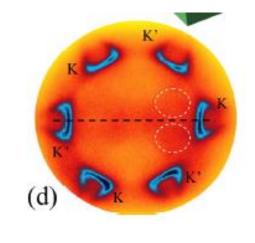


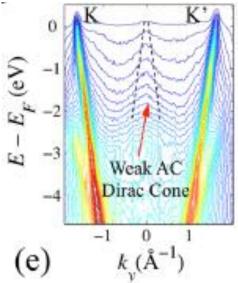


Nevius et al., Nano Lett. (2014) Palacio et al., Nano Lett. (2014)

Using ARPES to probe GNRs/SiC



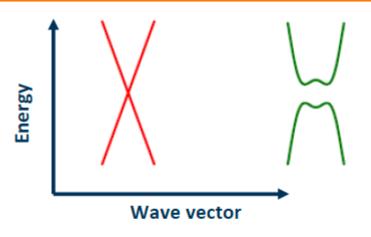






Nevius et al., Nano Lett. (2014)

2D Materials – An (Incomplete) Overview





X-enes

- Graphene
- Silicene
- Germanene

†

No gap, E_G = 0! This is really a pitty, since the missing gap causes serious problems for transistors. BLG

120

 $E_{\rm G} \le 130 \, {\rm meV}$ Too narrow for logic transistors.

X-enes

- Phosphorene
- Stanene
- GNRs

MX-enes

- Sc₂CF₂
- TiCO₂

X-anes

- Graphane
- Silicane
- Germanane

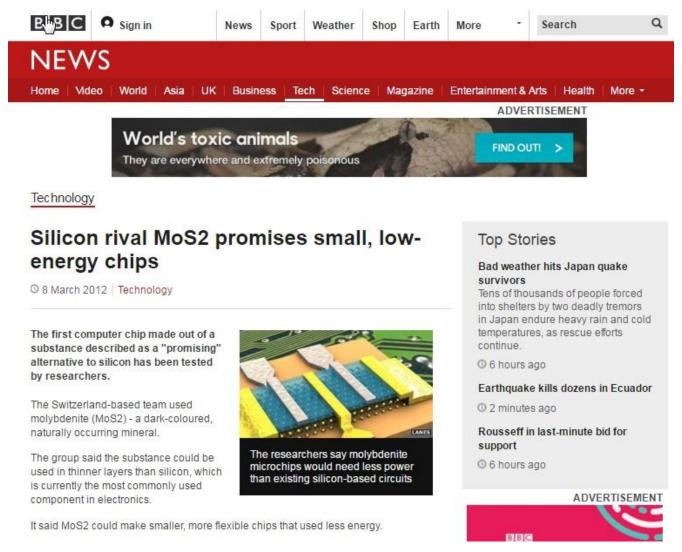
2D TMDs

- MoS₂, MoSe₂, MoTe₂
- WS₂, WSe₂, WTe₂

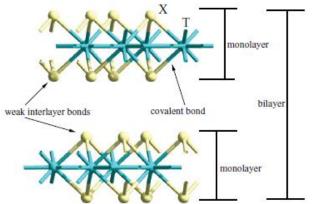
etc., etc.

Many of these materials have a gap $E_G = 0.5... 2.5 \text{ eV}$, perfect for transistors.

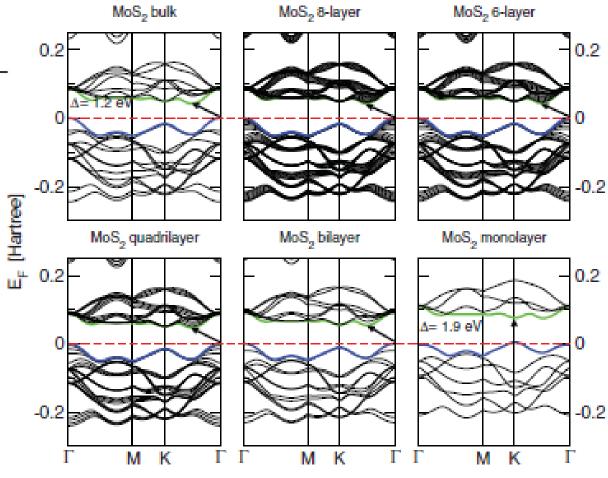




A demonstration of electric transistor fabricated with monolayer MoS_2 shows high current on/off ratios of > 10^8 . Even the mobility ~ $200 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ is much lower than that in graphene. The large current on/off ratio originates from sizeable band gap in MoS_2 .

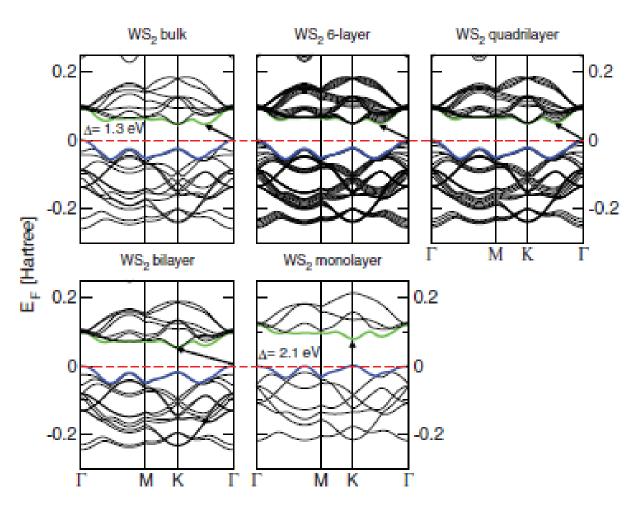


The band structure of MoS₂



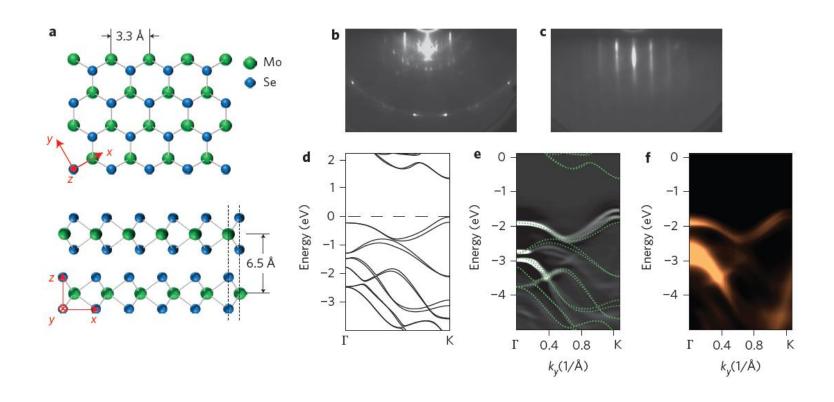


The band structure of WS₂

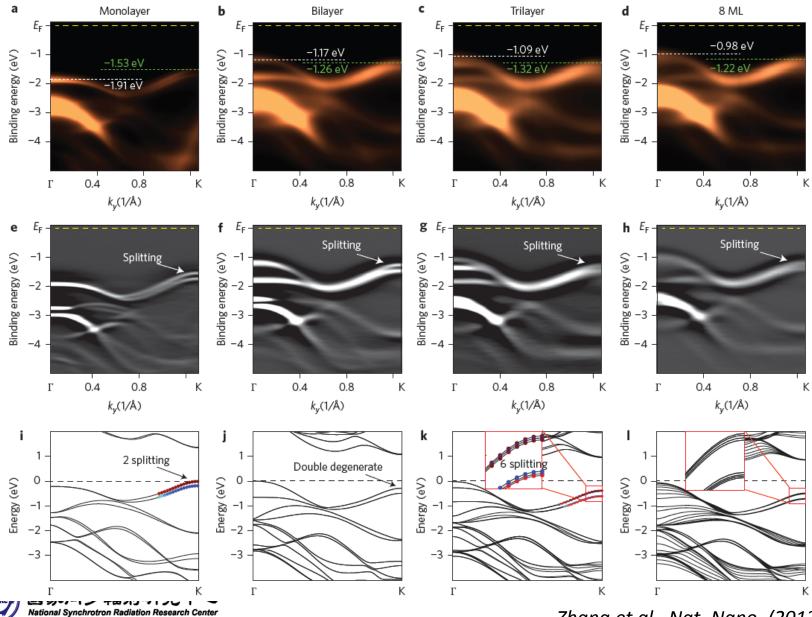




The electronic structure of MoSe₂

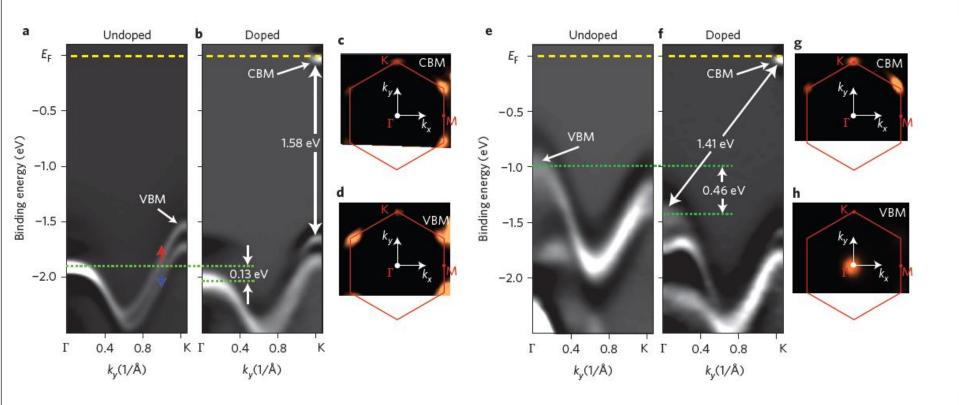






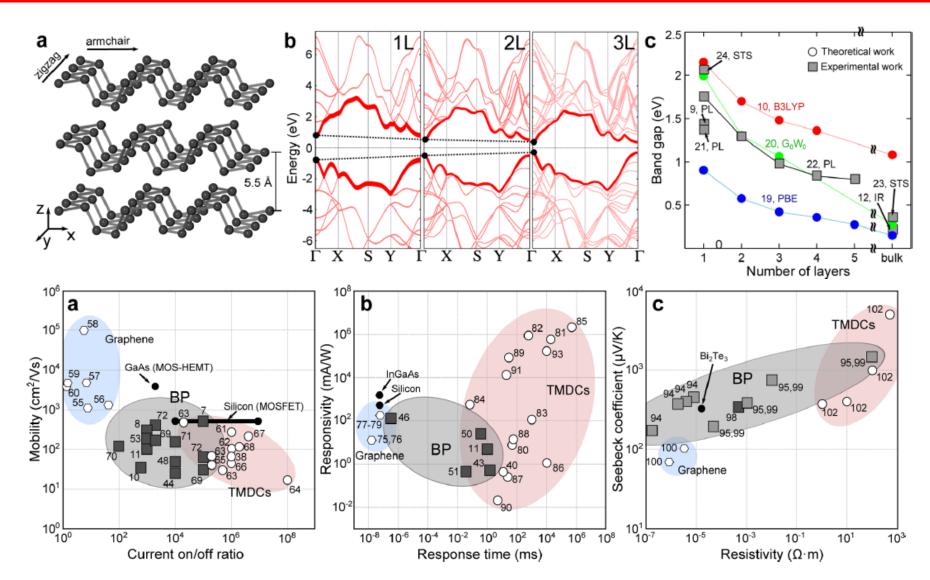
Zhang et al., Nat. Nano. (2013) ³

Alkali metal doped MoSe₂



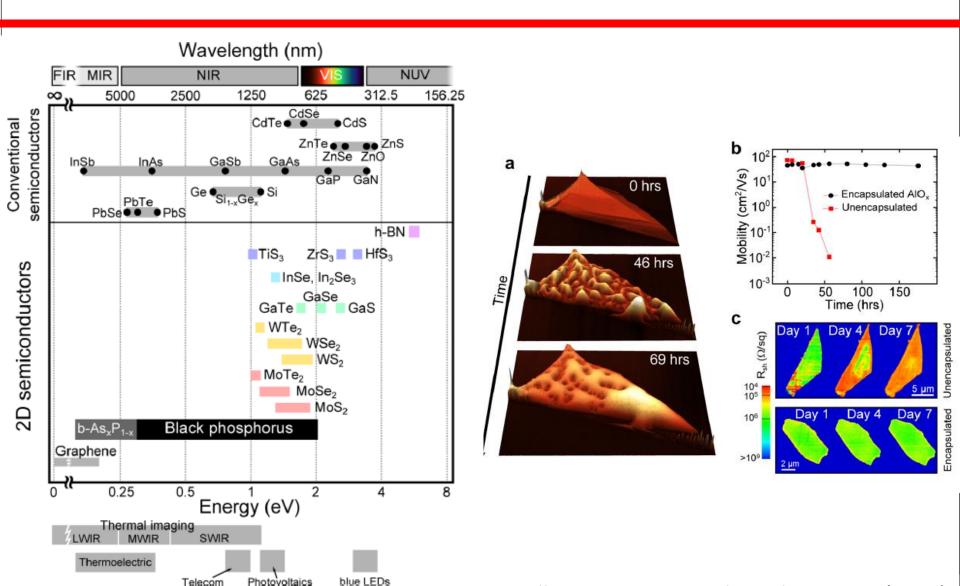


Black phosphorus (BP)



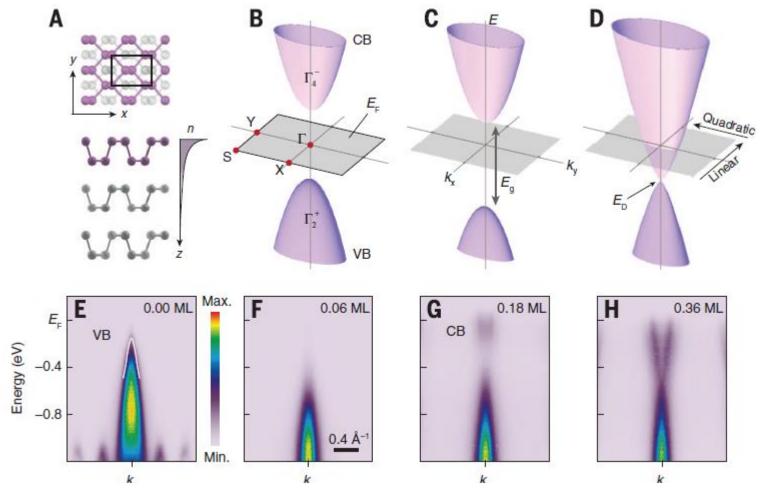
Catellanoas-Gomez, J. Phys. Chem. Lett. (2015)

The degradation of black phosphorus (BP)



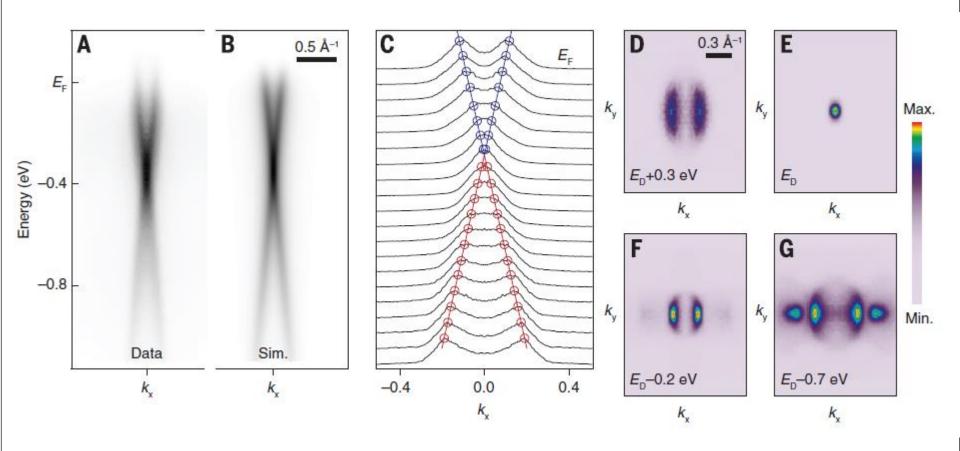
Catellanoas-Gomez, J. Phys. Chem. Lett. (2015)

Anisotropic Dirac semimetal state in BP

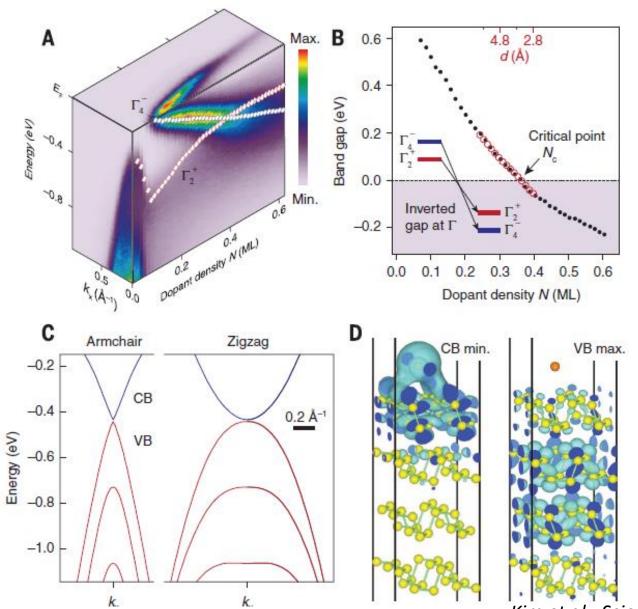




Anisotropic Dirac semimetal state in BP





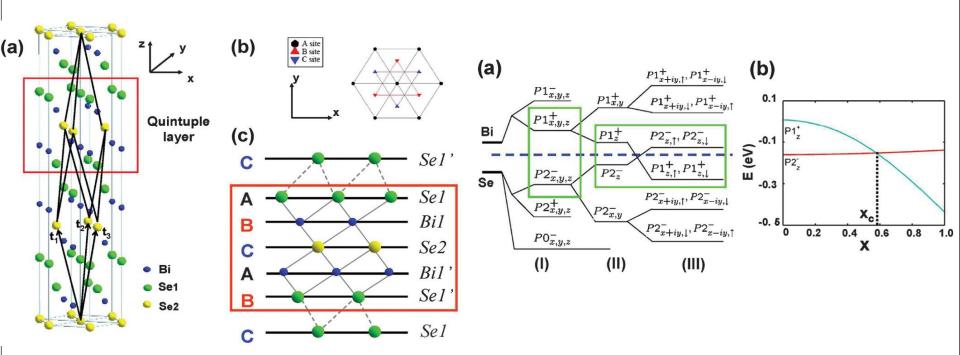




Kim et al., Science (2015)



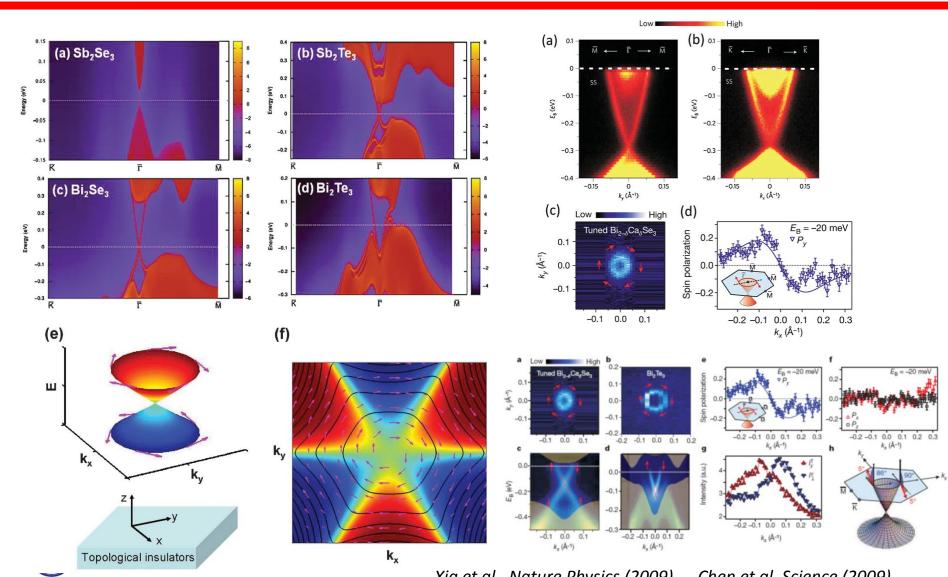
3D topological insulators



Strong spin-orbit coupling Induce the band inversion



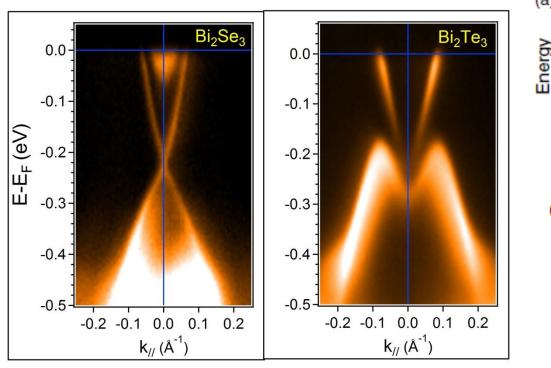
Predictions of 3D topological insulators

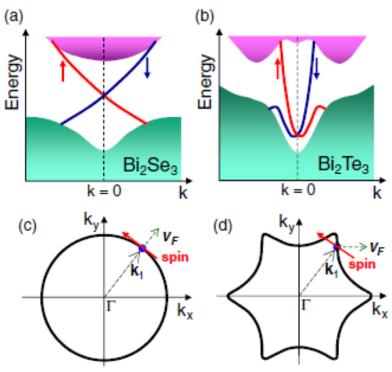


Xiao-Liang Qi and Shou-Cheng Zhang, RMP (2011)

Xia et al., Nature Physics (2009) Hsieh et al., Nature (2009) Chen et al, Science (2009)

Predictions of 3D topological insulators

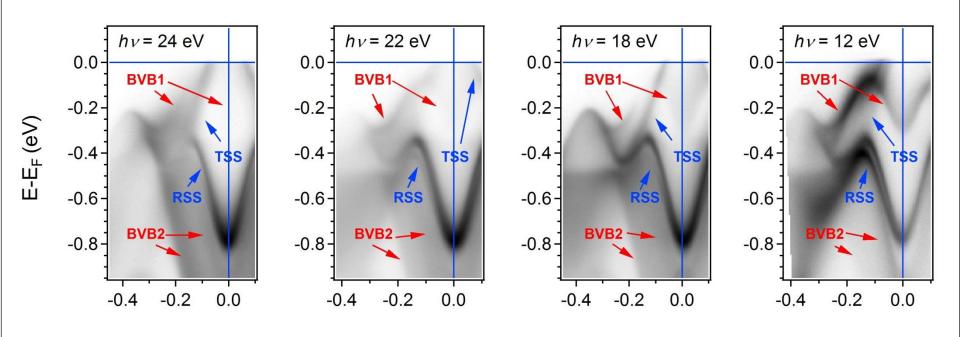




Spectra taken at BL21B1, NSRRC

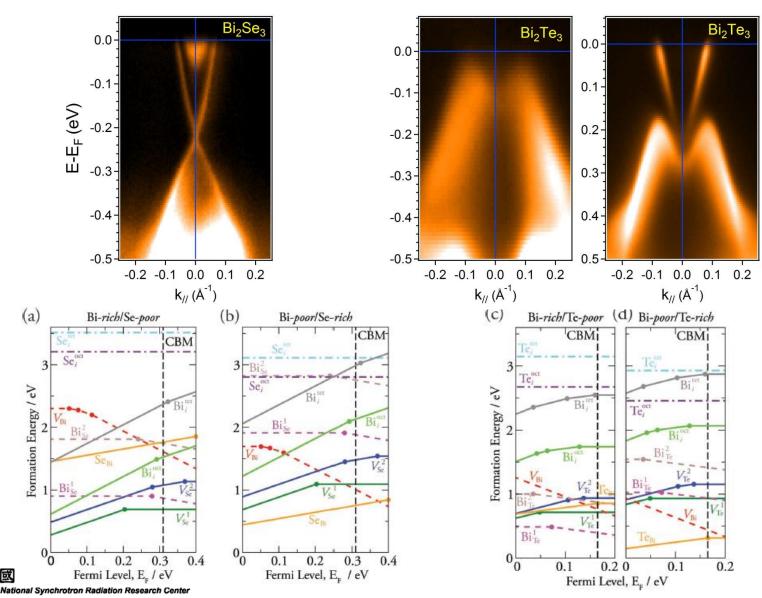


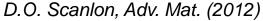
The electronic structure of Sb₂Te₃ insulators



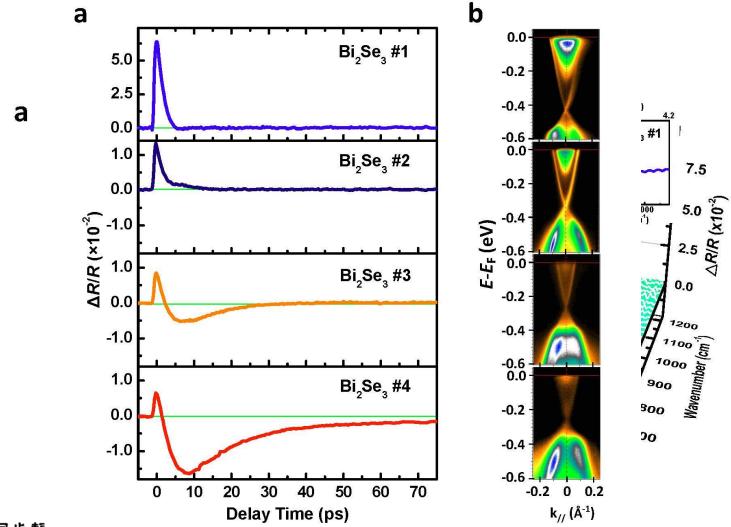


Initial growth condition of Bi family TIs

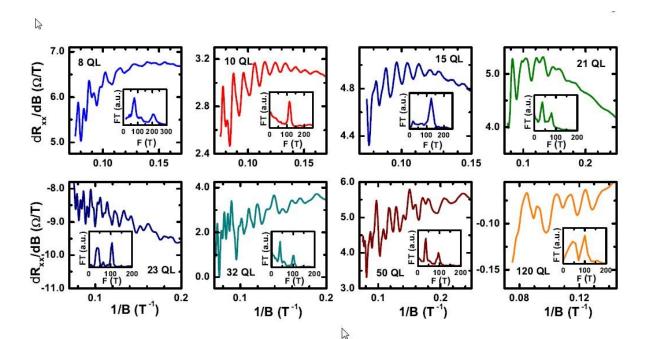




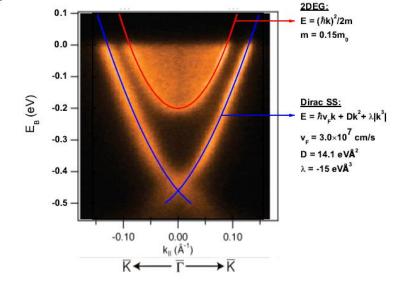
Ultrafast Dynamics of Dirac Fermion in Topological Insulators



Estimate the surface charge carrier density : *SdH* oscillations ($n_S = \frac{k_F^2}{4\pi}$)

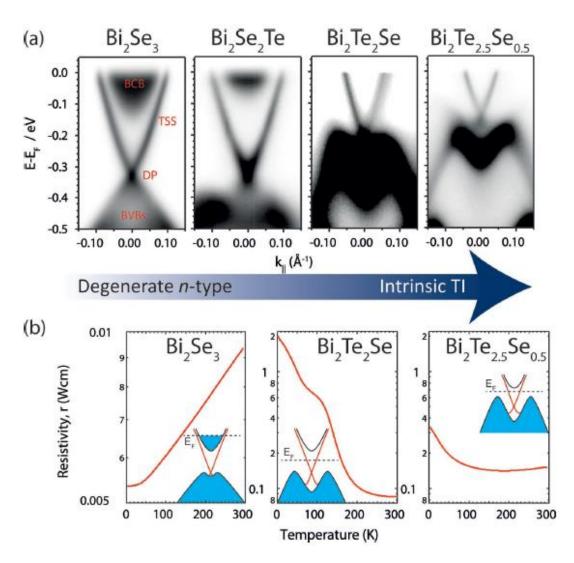


Estimate the surface charge carrier density : ARPES





Tuning the position of the Dirac point in ternary topological insulators

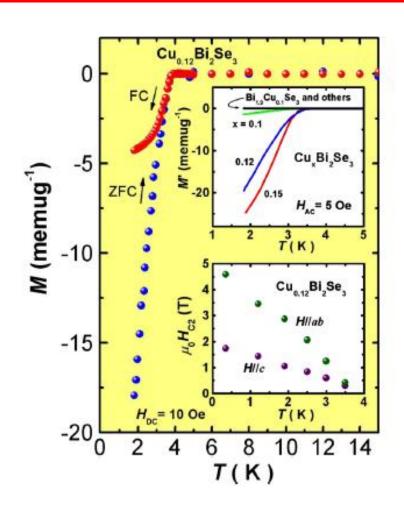


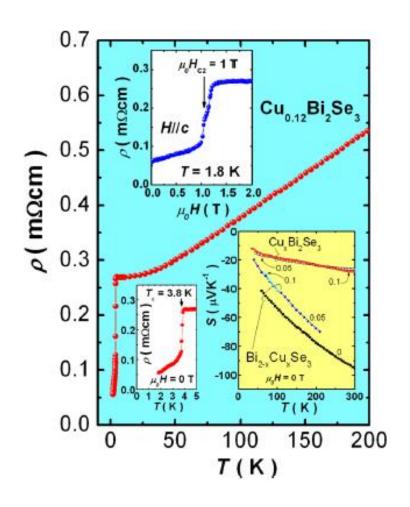


Another way is to dope topological insulators: Cu, Mn, Ca, C....



Superconductivity in Cu doped Bi₂Se₃ compound

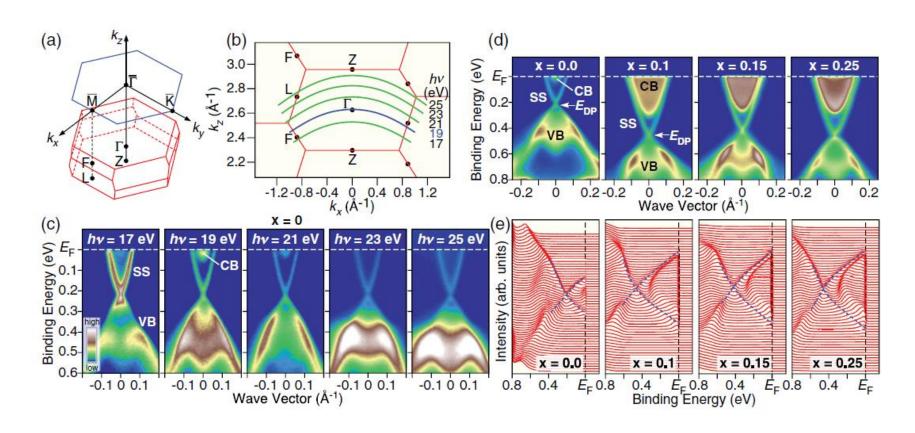




Hor et al., PRL (2010)

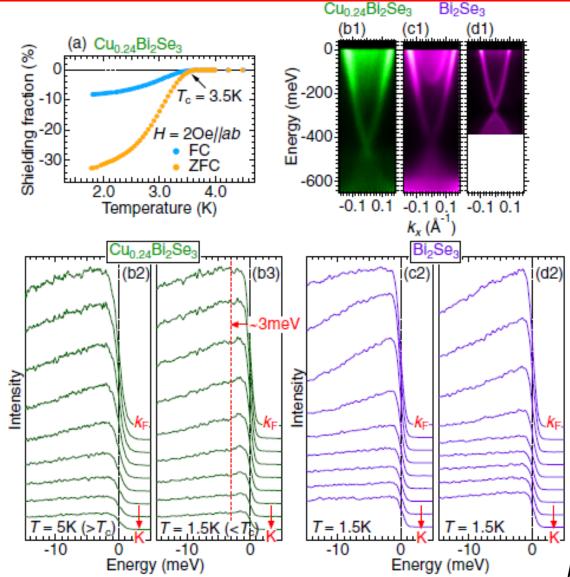
 $Cu_xBi_2Se_3$ for 0.1<x<0.15

Superconductivity in Cu doped Bi₂Se₃ compound





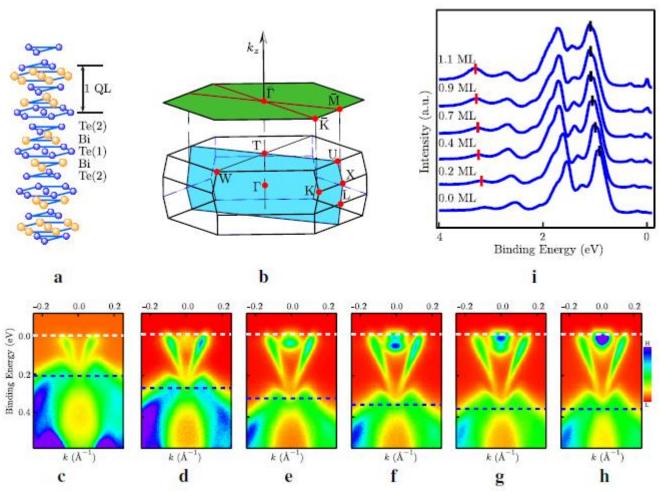
Superconductivity in Cu doped Bi₂Se₃ compound





Kondo et al., PRL (2013)

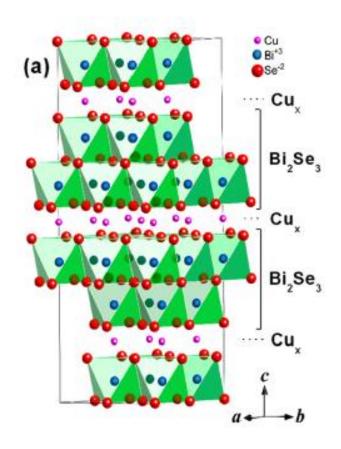
Cu doped epitaxial Bi₂Te₃ thin films





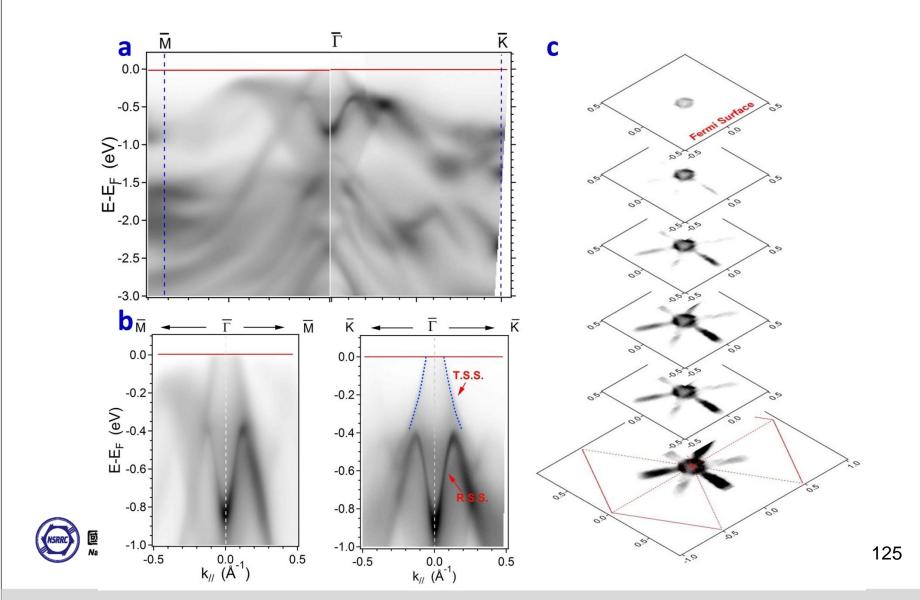
The role of Cu atoms in Cu doped Bi₂Se₃ and Bi₂Te₃ topological insulators

Cu_xBi₂Se₃ or Bi_{2-x}Cu_xSe₃?

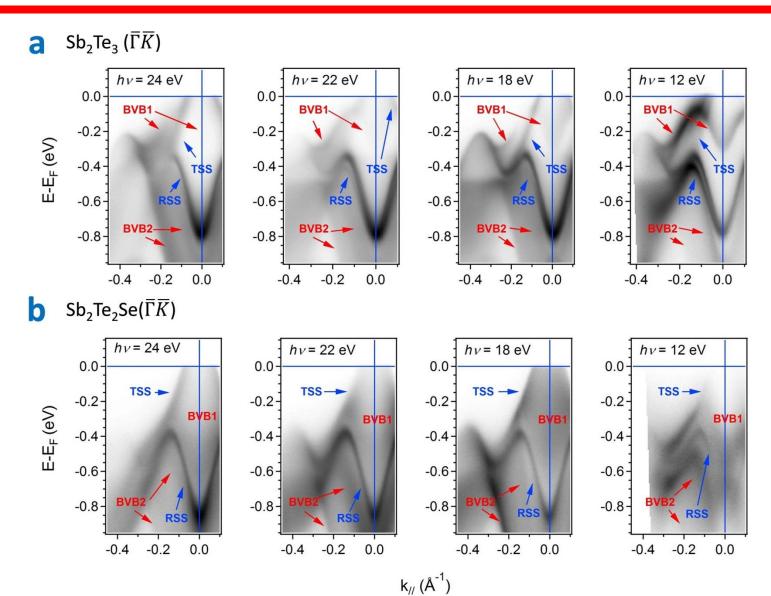




The electronic structure of Sb₂Te₂Se

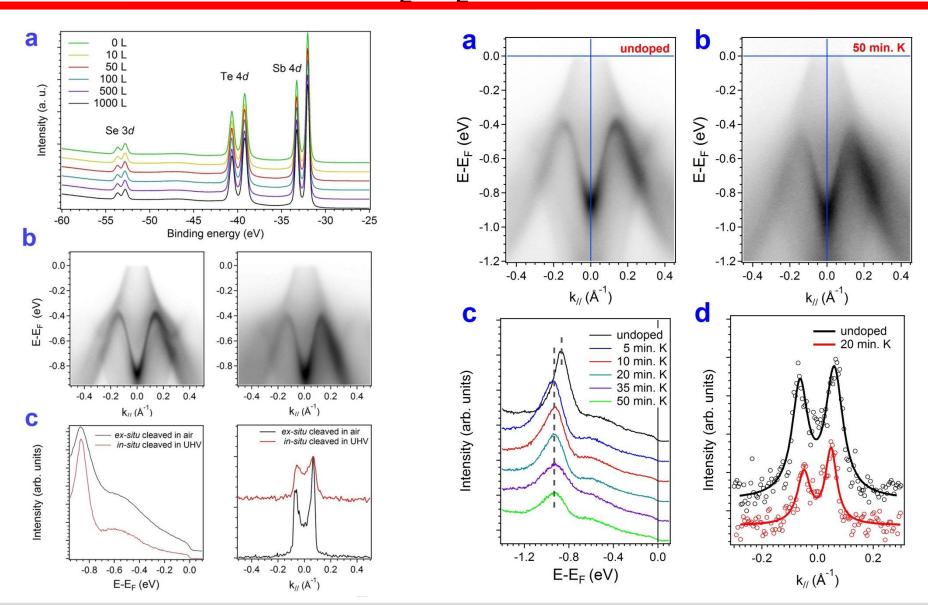


Comparison of Sb₂Te₃ and a Sb₂Te₂Se





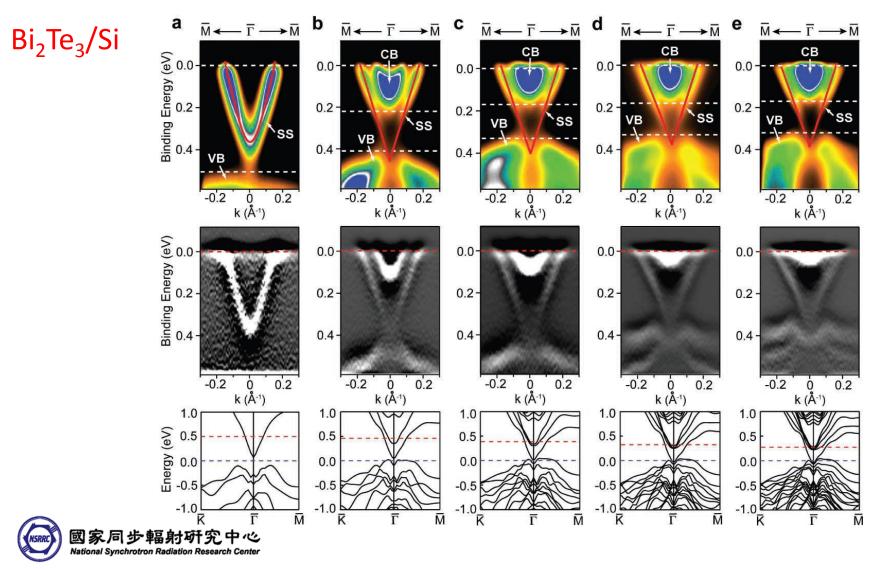
Robustness of a Topologically Protected Surface State in a Sb₂Te₂Se Single Crystal



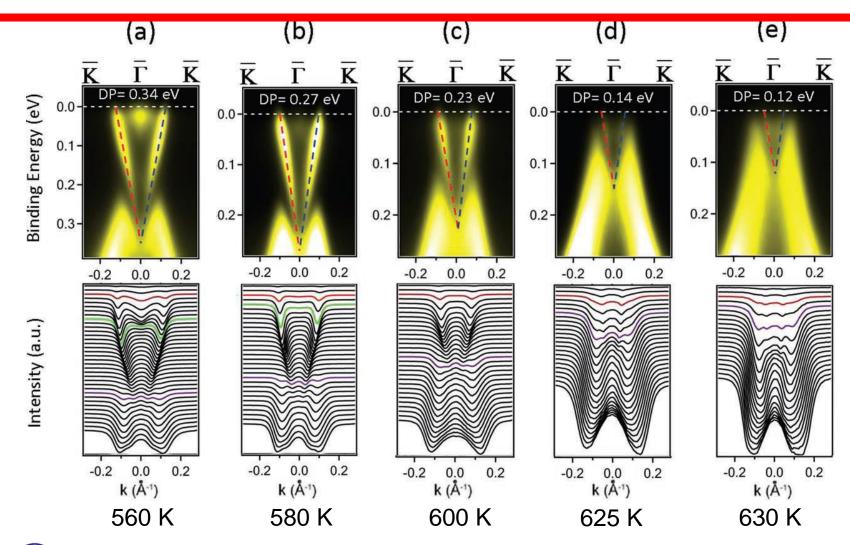
Toward future electronic devices



MBE growth topological insulators (Bi₂Te₃)

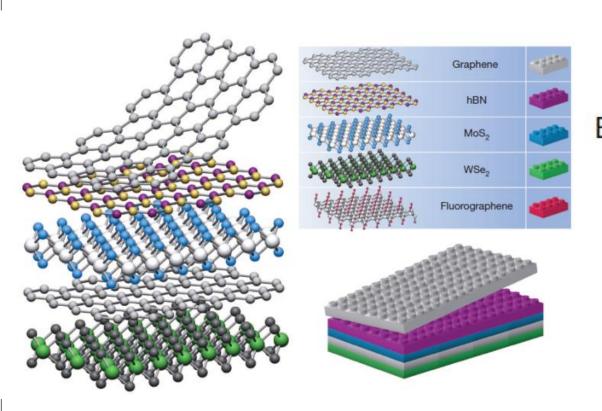


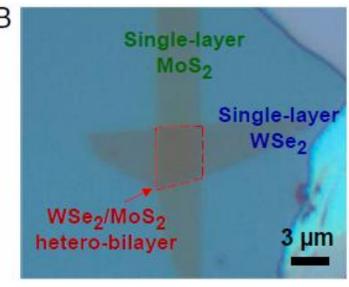
Temperature effect on MBE growth TIs





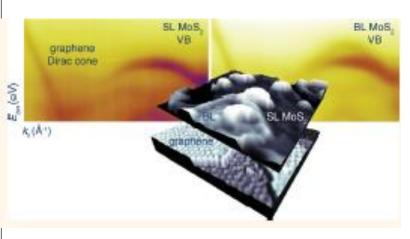
Van der Waals heterostructure

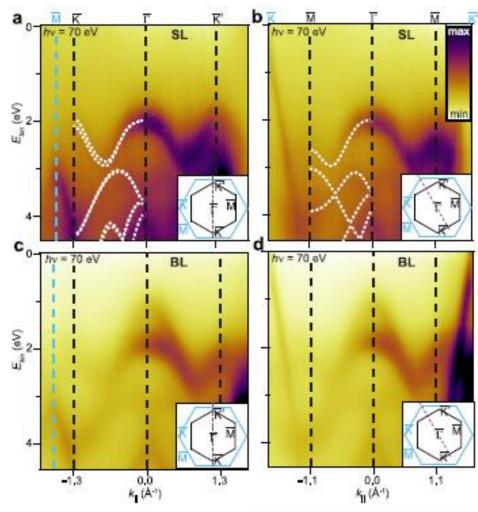






Van der Waals heterostructure : MoS₂/graphene

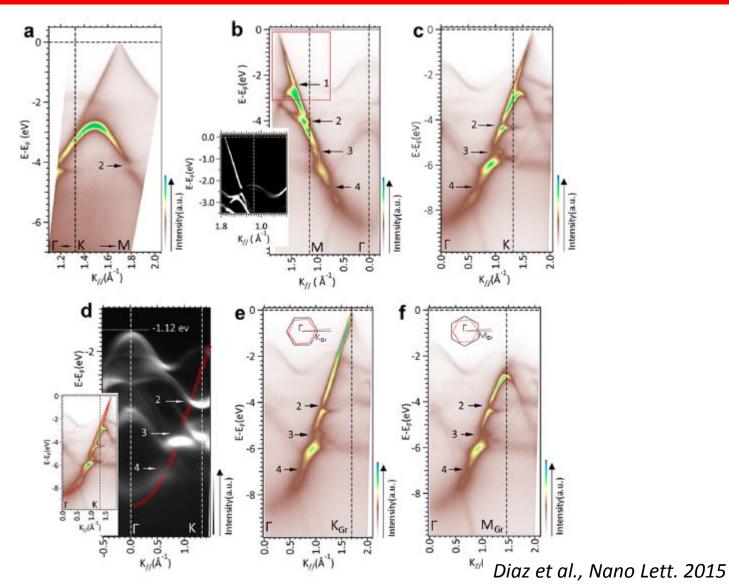






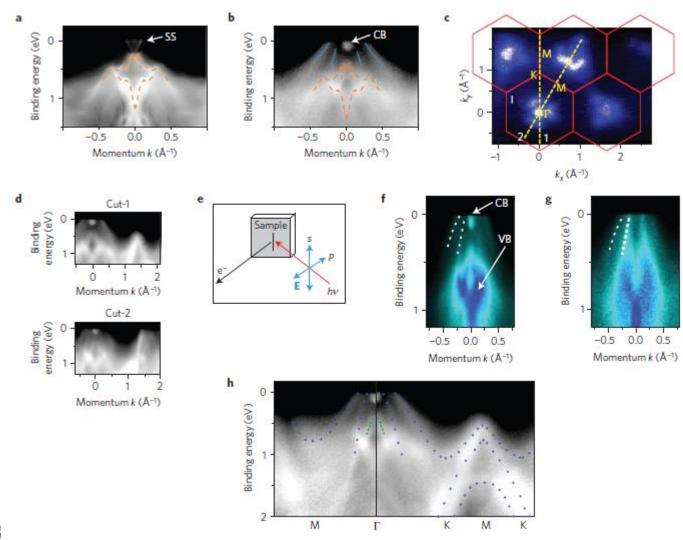
Miwa et al., ACS Nano (2015)

Van der Waals heterostructure : Graphene/MoS₂



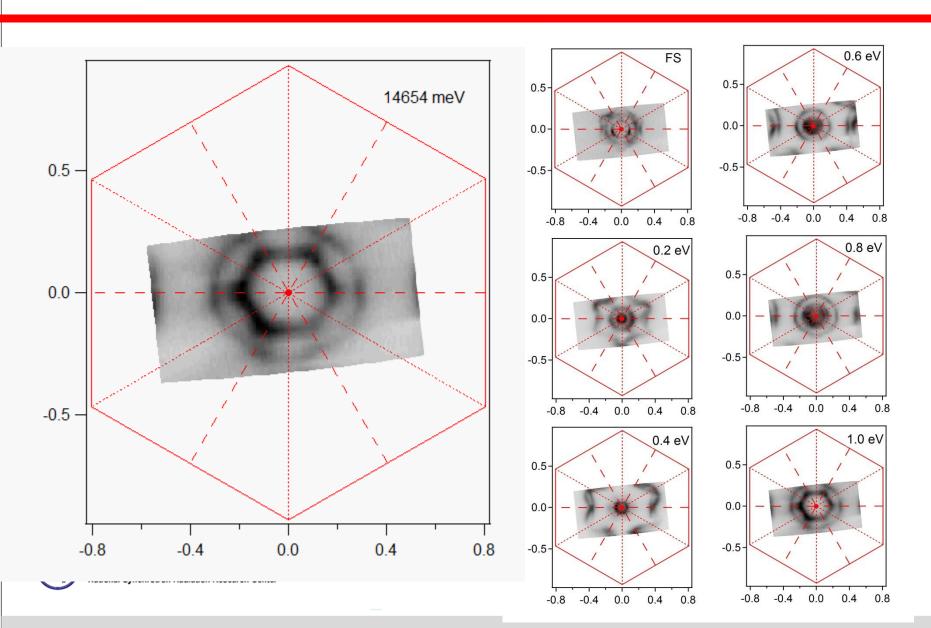


Hybrid nanostructure: Stanene/Bi₂Te₃





Single Bi bilayer/Bi₂Se₃



Summary

- ARPES can provide a deeper insight for the understanding of electronic property in 2D materials.
- A combination with other tools, such as XPS, XAS, STM, pumpprobe experiment ...etc., can establish better model to explain novel phenomena in emergent materials
- A cooperation with theorists is necessary for ARPES guys.
- Hungry for high quality single crystal or thin film



